

Techno CLS,

Work Package 3, Experimental issues, Part 1

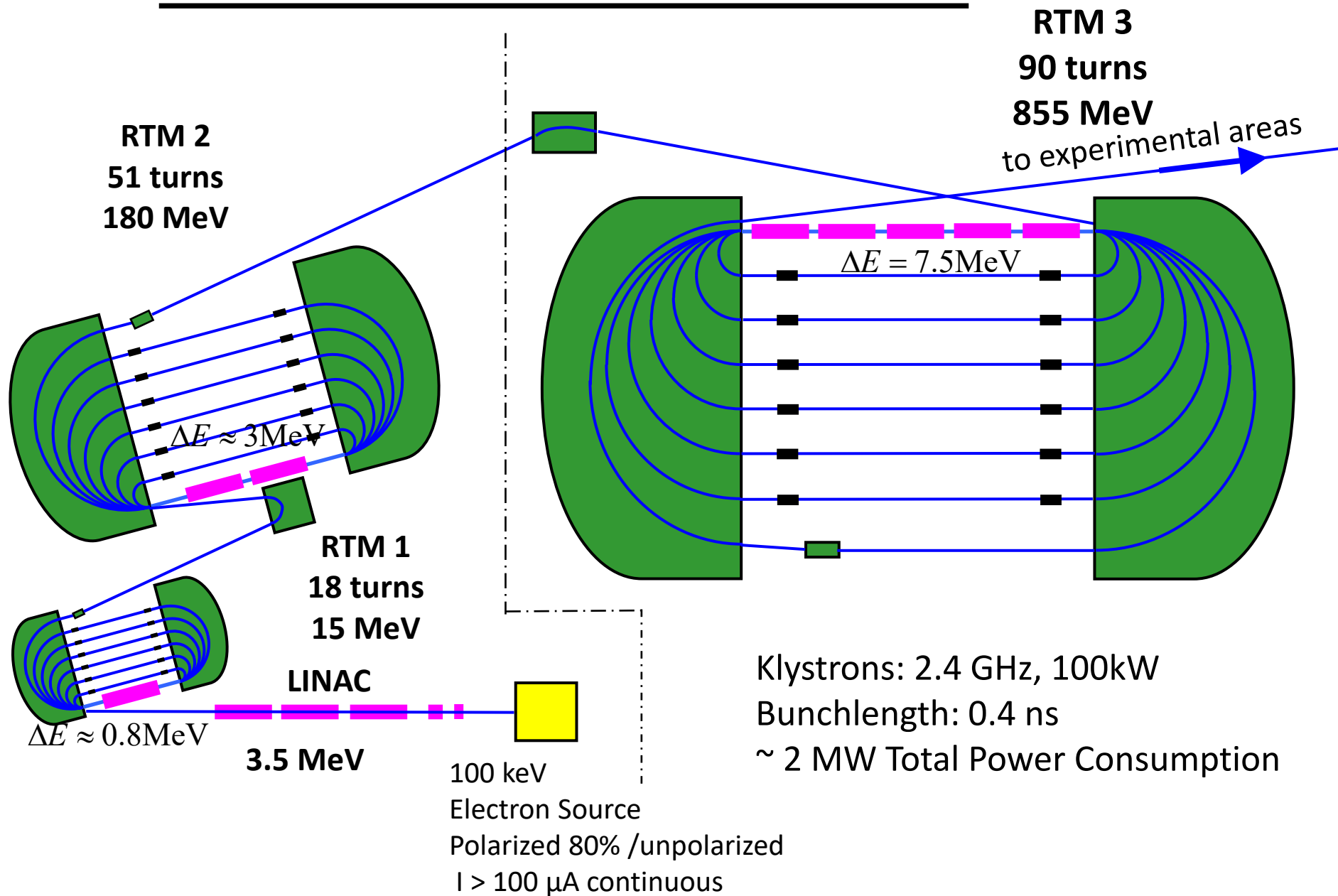
Experiments @ MAMI

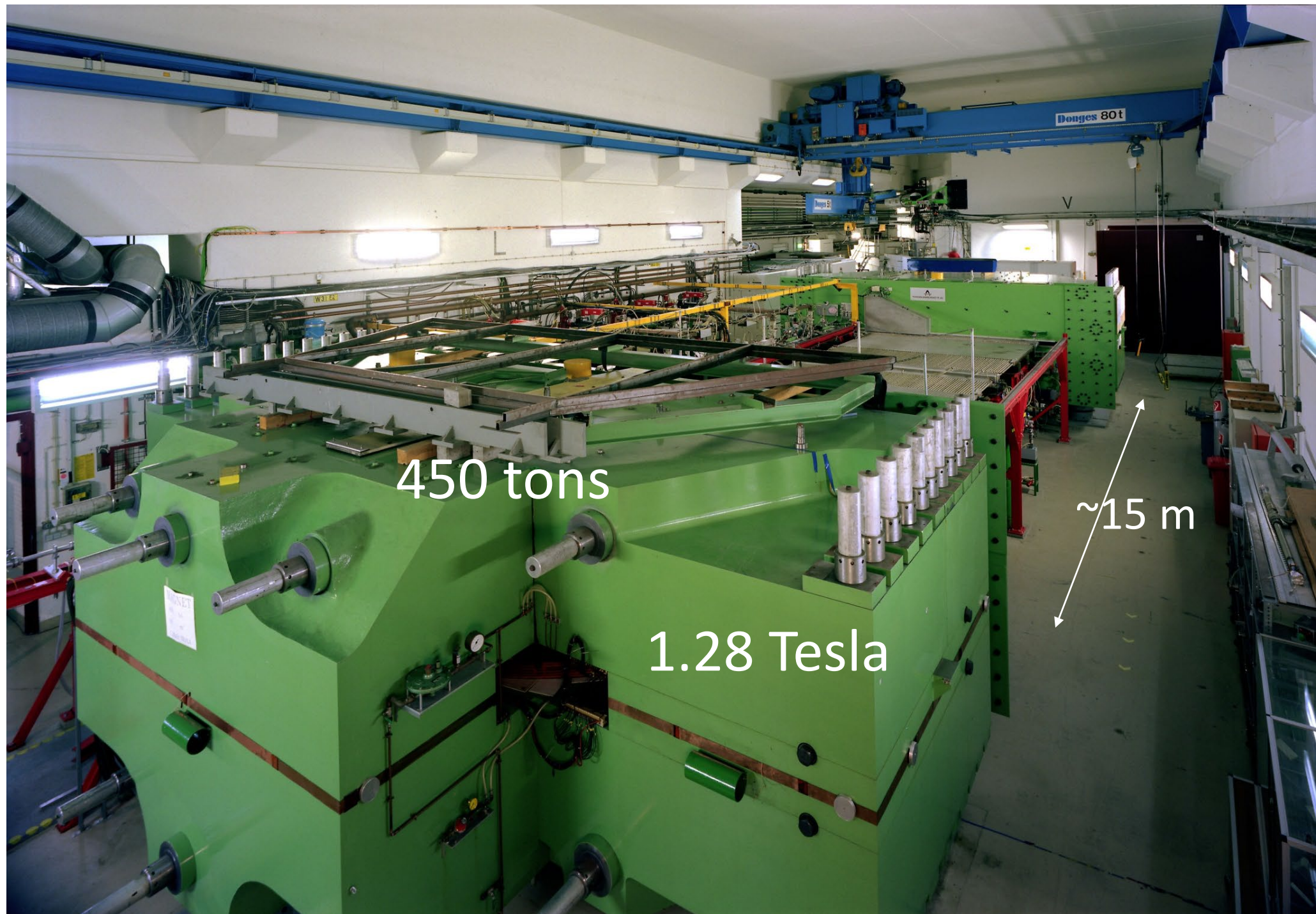
Objectives

- *O3.5 Channeling experiments with electrons and (positrons) in LC, BC and PBC crystals.*
- *O3.4 Construction of a beam transport system for monochromatic low divergence 530 MeV positrons.*

Experimental issues, Part 2 -> Talk Vincenzo Guidi WP3

Mainzer Mikrotron MAMI B





450 tons

1.28 Tesla

~15 m

Ground plan of MAMI

$E = 180 \text{ MeV} - 1600 \text{ MeV}$

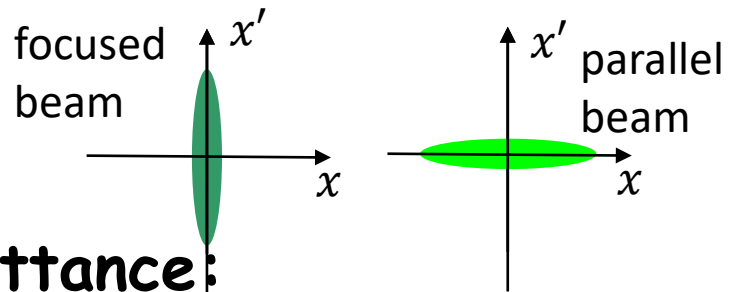
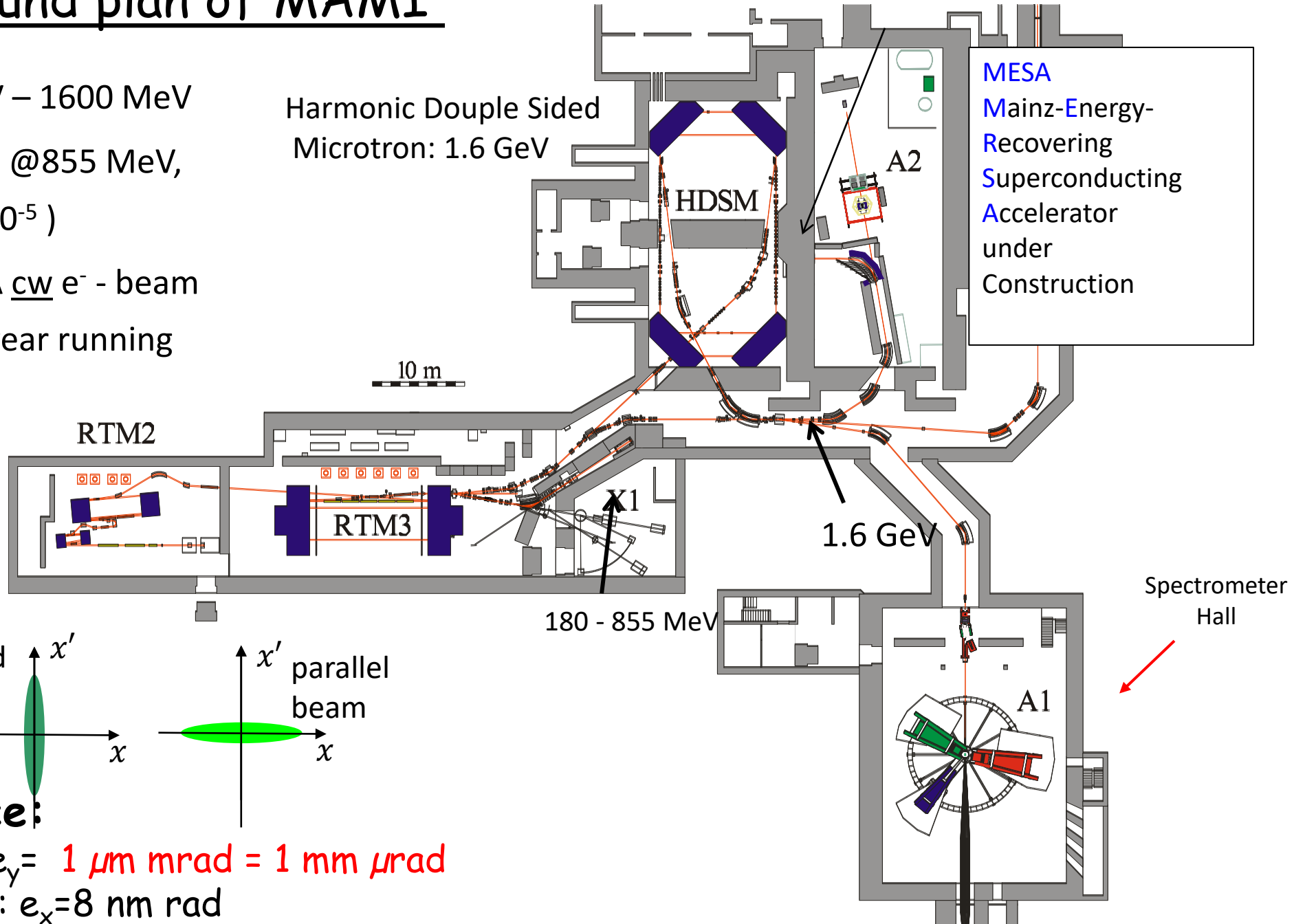
$\Delta E = 13 \text{ keV @ } 855 \text{ MeV}$,

$\Delta E/E = (2 \cdot 10^{-5})$

max. $100 \mu\text{A}$ cw e^- - beam

$\sim 7000 \text{ h / year}$ running

Harmonic Double Sided
Microtron: 1.6 GeV



Emittance:

Vertical : $e_y = 1 \mu\text{m mrad} = 1 \text{ mm } \mu\text{rad}$

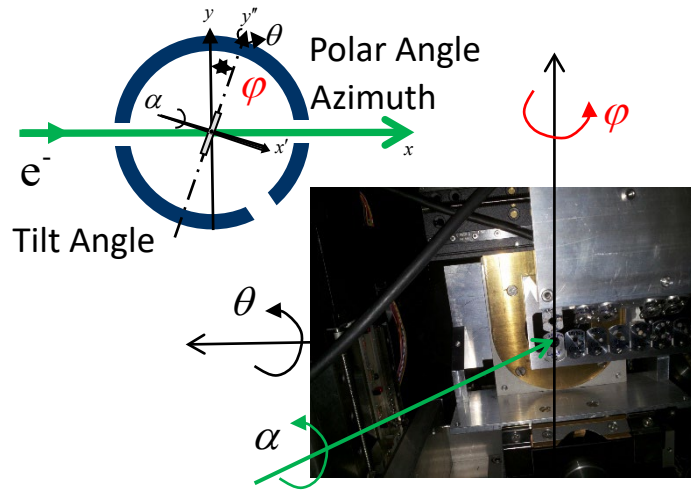
Horizontal: $e_x = 8 \text{ nm rad}$

Task T3.5

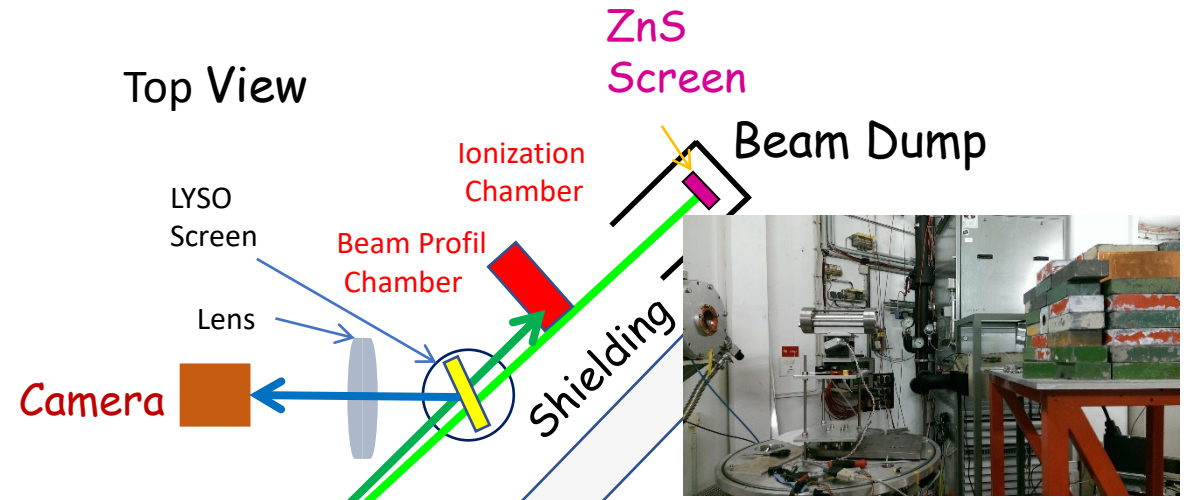
Measurement of radiation produced with channelled electrons (and positrons).

Experimental Setup (855) MeV e^-

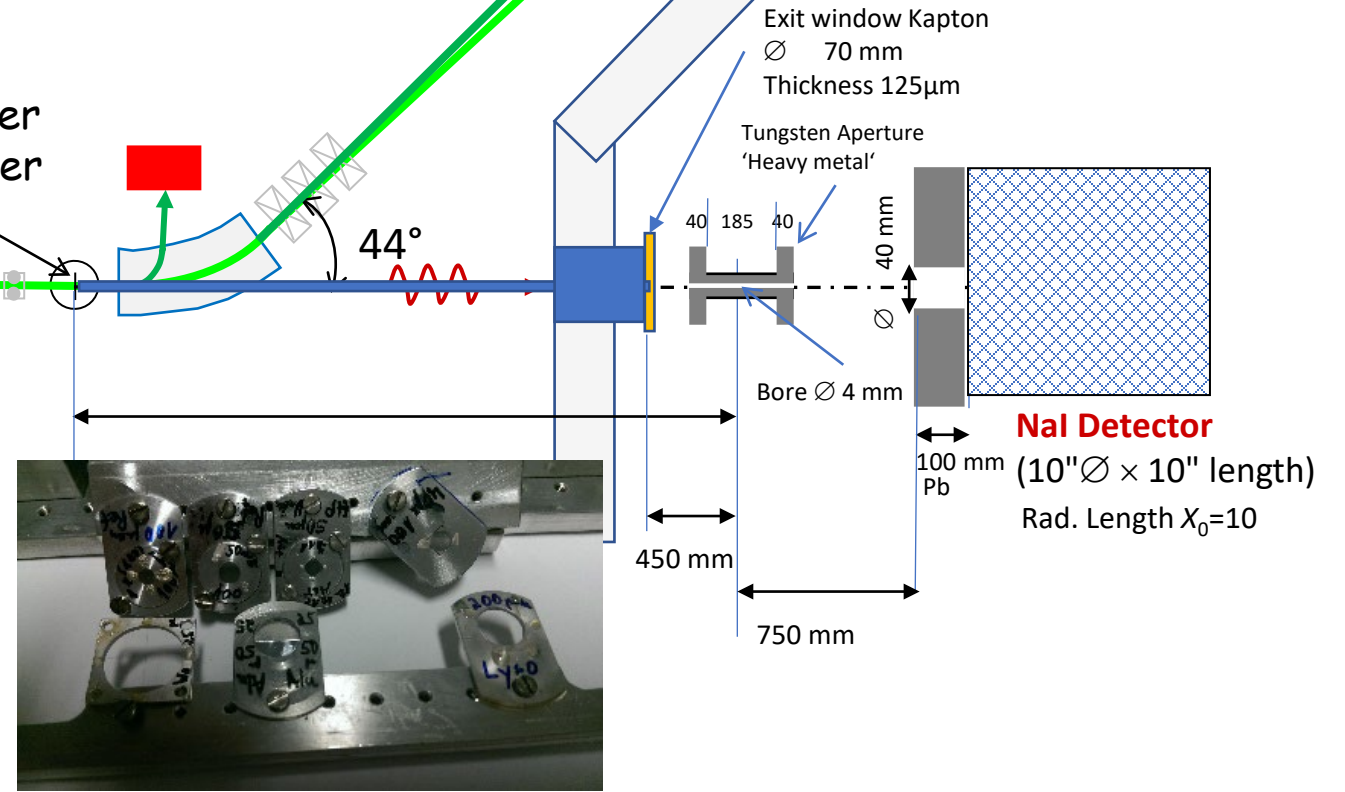
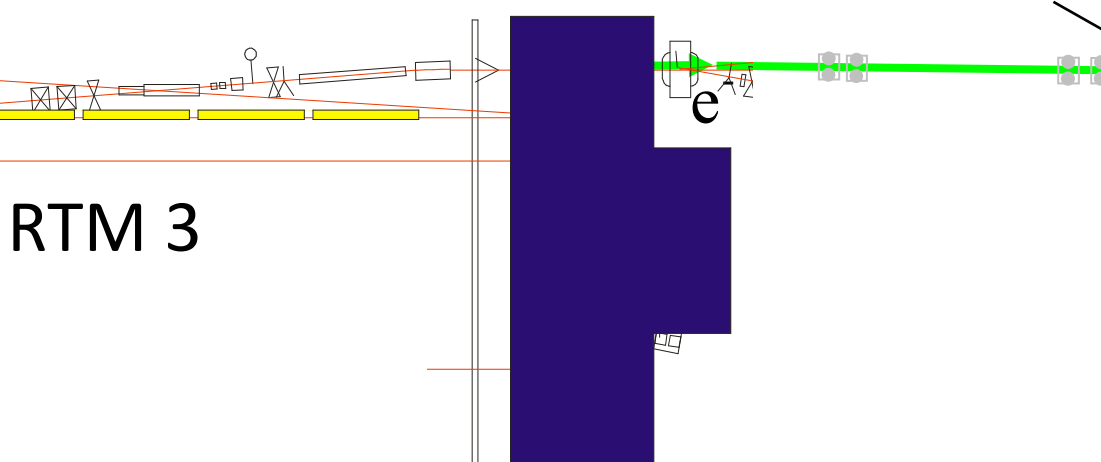
Top View



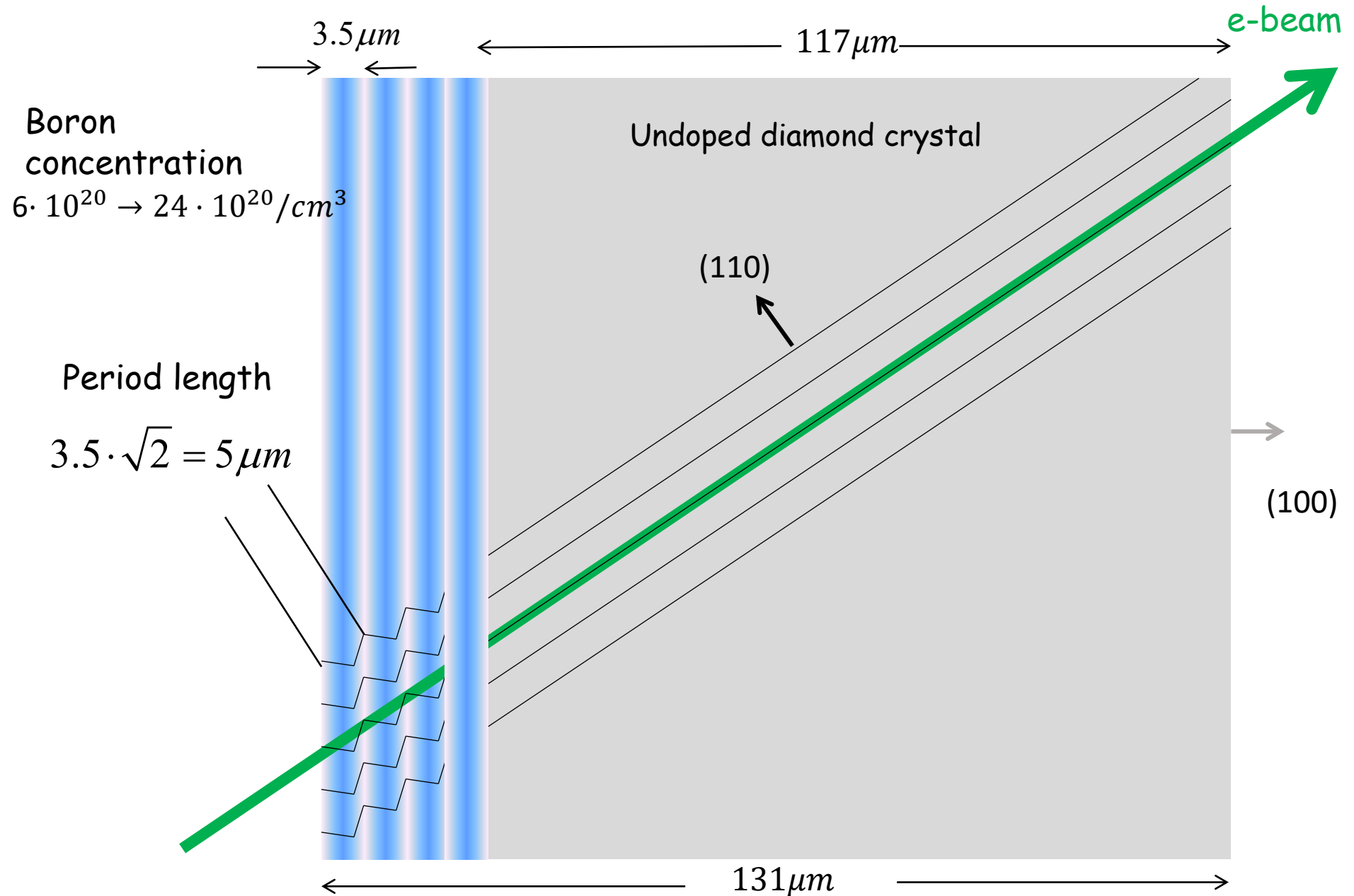
Top View



Target Chamber with Goniometer

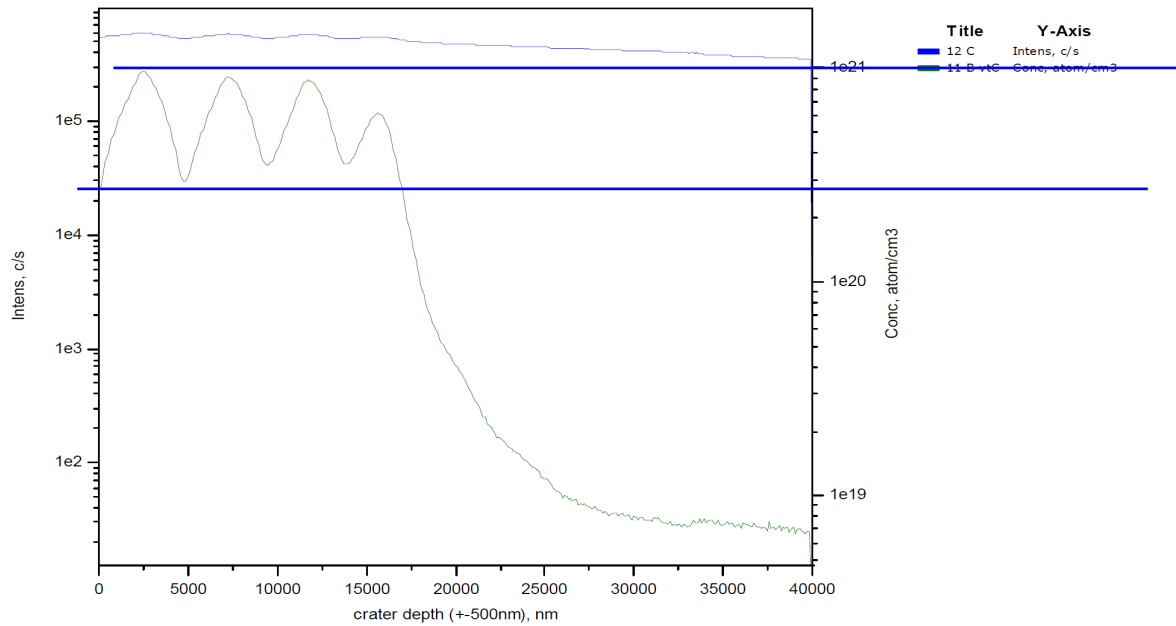


'New' 4 Period Diamond Undulator



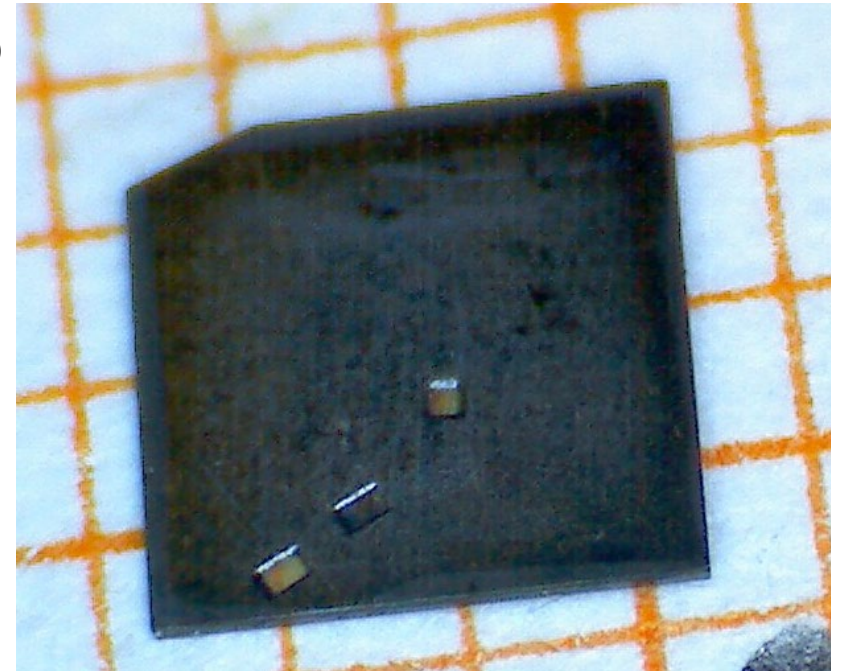
SIMS Profile - Bor concentration

Sample: W170802-D2 Mitte Diamant-Bor_5kOx -11562 (4" Sample Holder (d110)-Default) Cameca IMS 9/29/2017
Data file: W:\Diamant\CVD_Bor\Sonstige\W170802-D2\11562_W170802-D2_Mitte_Diamant-Bor_5kOx_29.09.17_14.33.2f2f-0\W170802-D2_Mitte_Diamant-Bor_5kOx -11562 Depth Profile
Flig Oxygen Ip: 4.01e+03/1.03e+03nA
Comments: Ox 5kV, 216nA; Vt 12C-> atomar,Temp# 11561



$$9 \cdot 10^{20} / \text{cm}^3 = 0.5\%$$

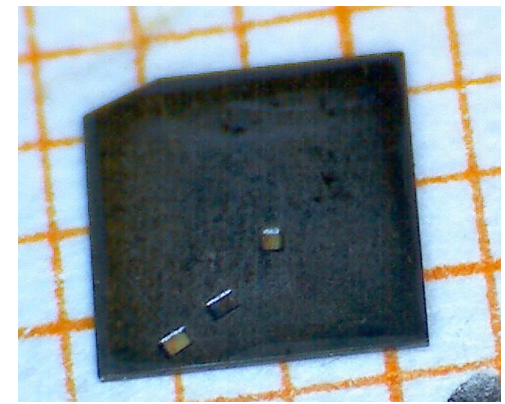
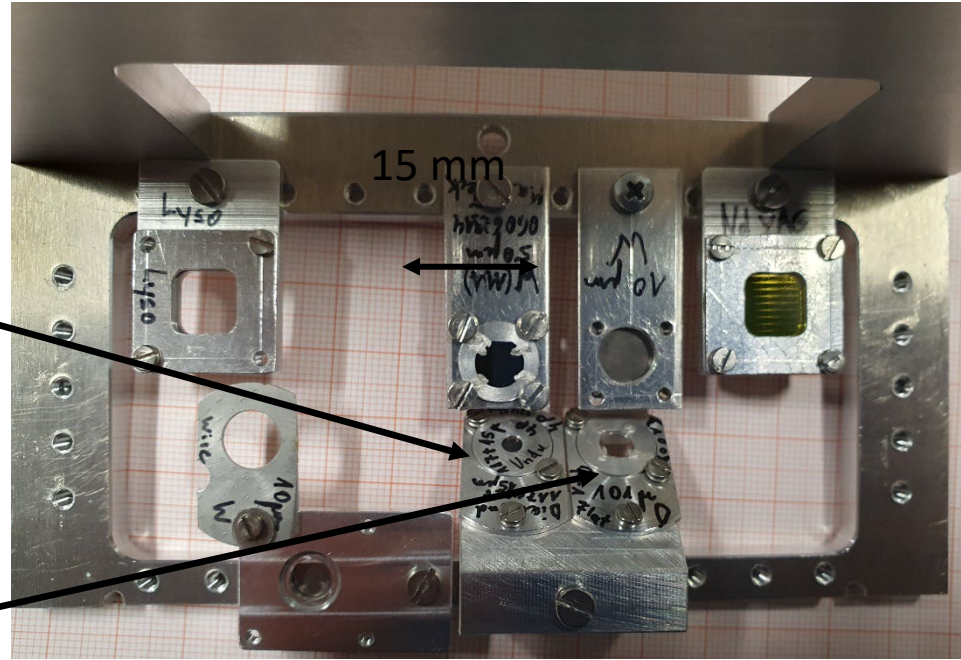
$$3 \cdot 10^{20} = 0.17\%$$



Talk of Rebecca Dowek

4 period
Diamond crystal

101 μm flat
Diamond crystal
reference

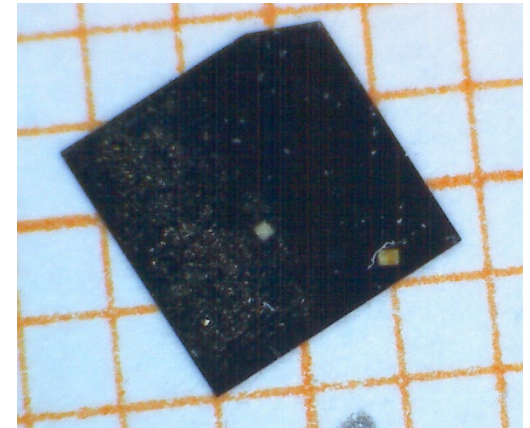


SIMS
holes

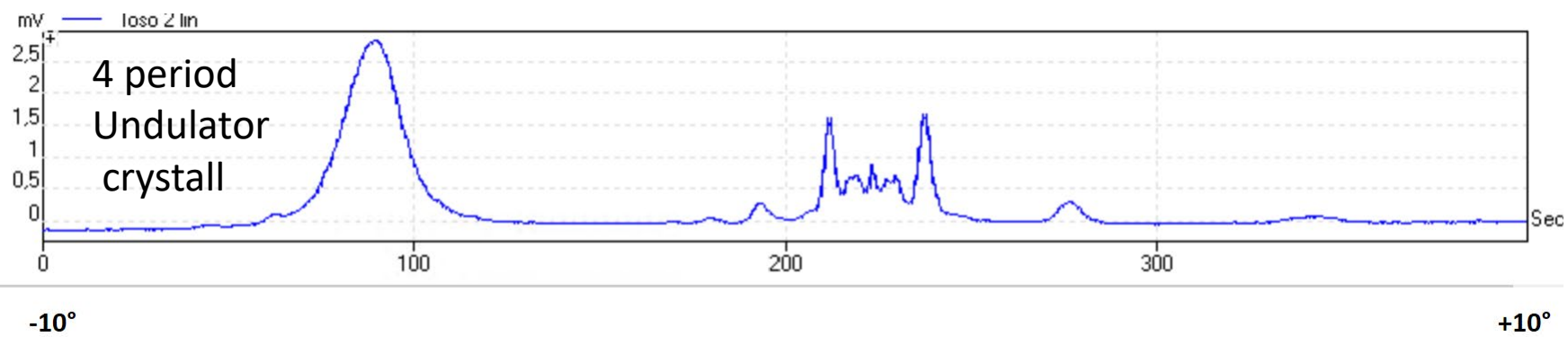
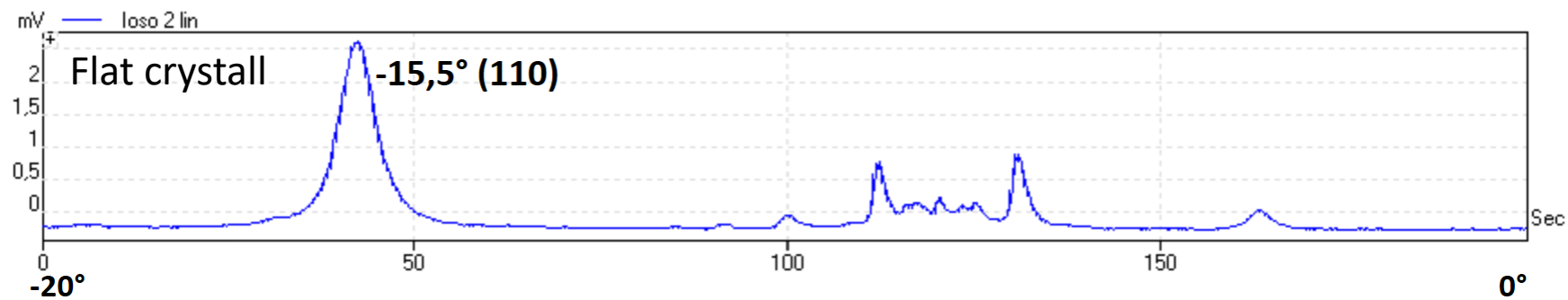
4 period
Diamond crystal
Flip configuration



45°



Scans with Ionisation chamber

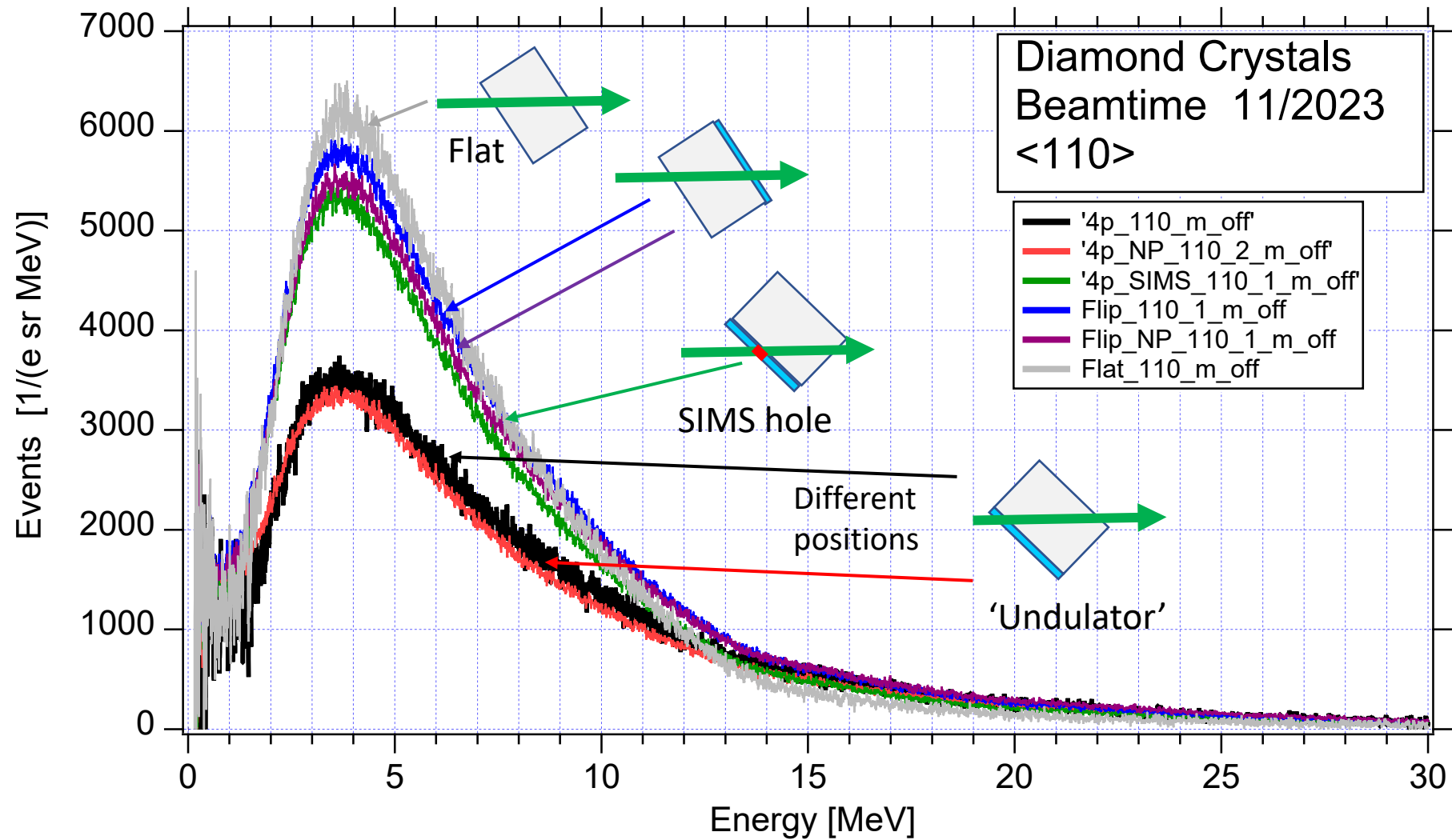


4 Period Diamond crystal, 855 MeV

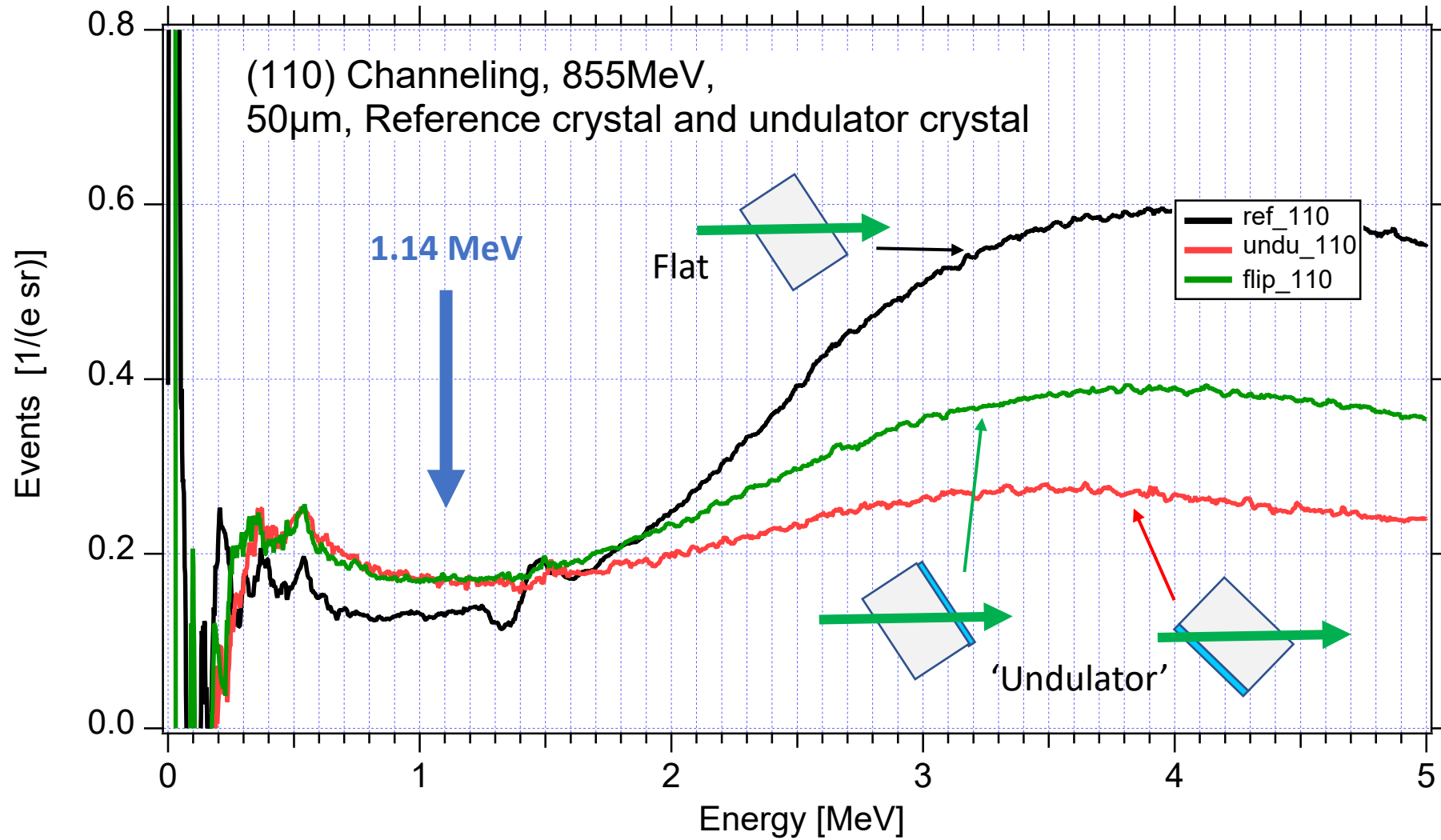
$$\hbar\omega = k \frac{4\pi \cdot \gamma^2 \hbar c}{\lambda_U (1 + K^2 / 2 + \gamma^2 (\theta_x^2 + \theta_y^2))} = 1.136 \text{ MeV}$$

at $\theta_x = \theta_y = 0$, and first order $k = 1$

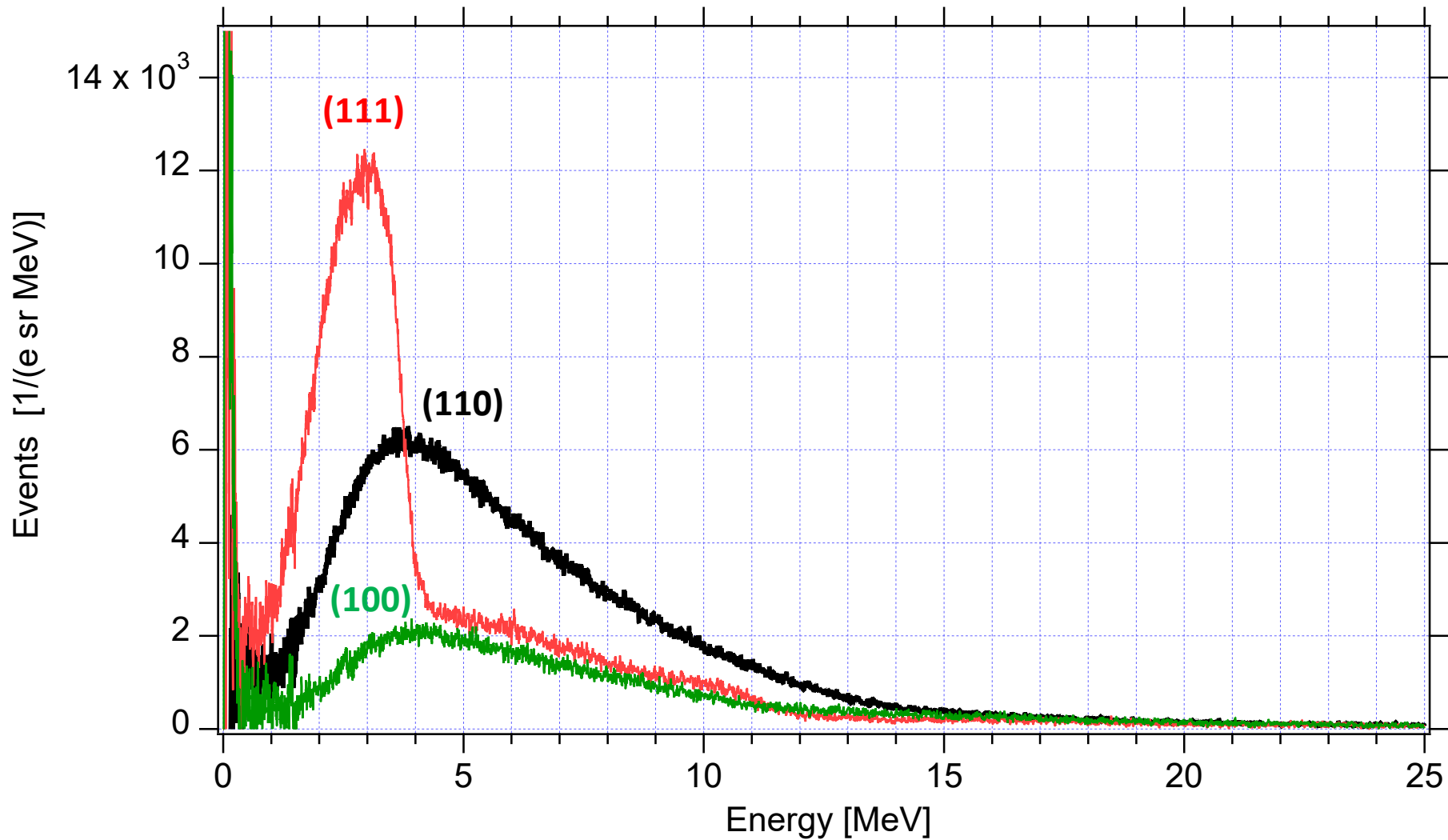
Comparison 'Undulator' - Reference crystal
(110) plane (Undulator plane)
Off axis radiation subtracted



Comparison 'Undulator' - Reference crystal (110) plane (Undulator plane)



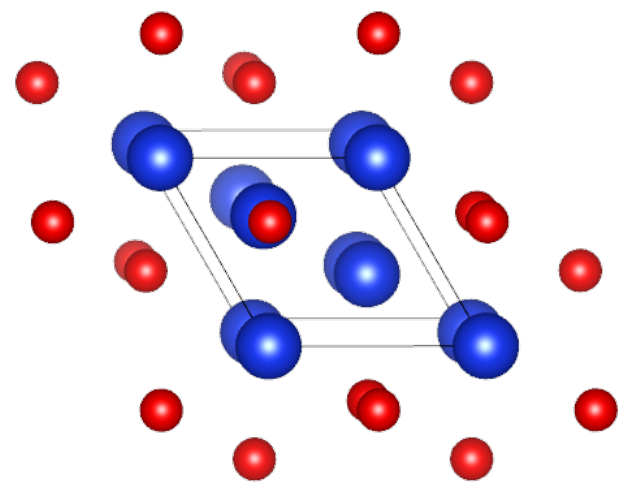
Channeling radiation of a flat diamond crystal



Channelling Radiation in Silicon Carbide

Exploration of a **new material** beside Silicon and Germanium

Low Z- atoms



Silicon Carbide 6H
<0001> axis

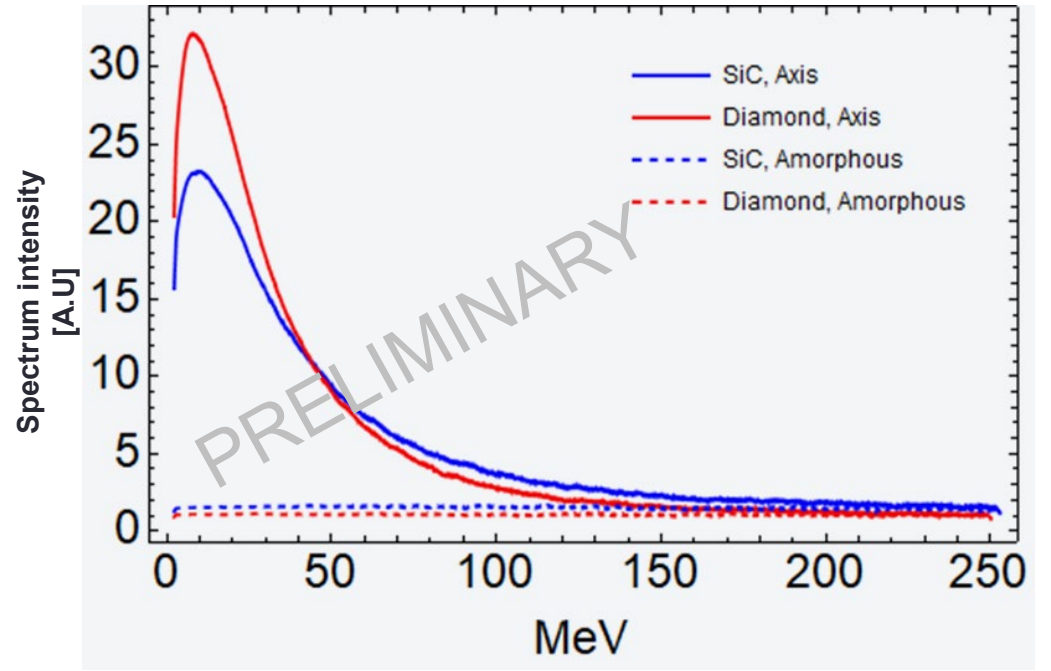


LINEAR CRYSTAL
0.33 mm thickness, 4x7
mm² surface
channelling Axis: <0001>

attice structure: Hexagonal
(Space group #186)

Tightly packed planes perpendicular to <0001>, featuring properties in between Si and C, being cheaper than Diamond.

e- @855 MeV



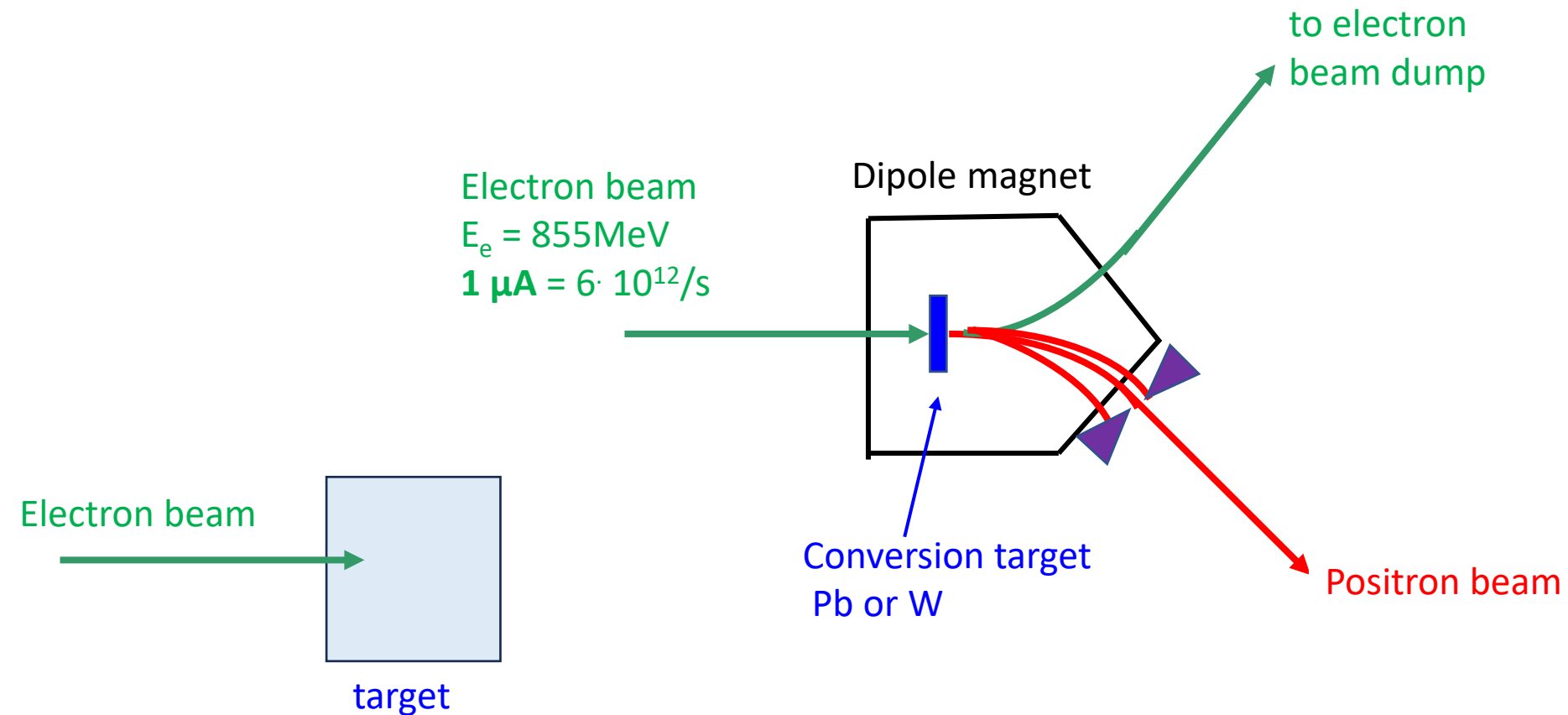
SiC 6H crystal: 0.33 mm thick axis <0001>
Diamond crystal : 0.31 mm thick , axis <100>

Objective 3.4

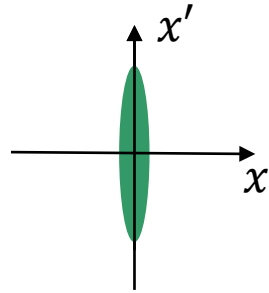
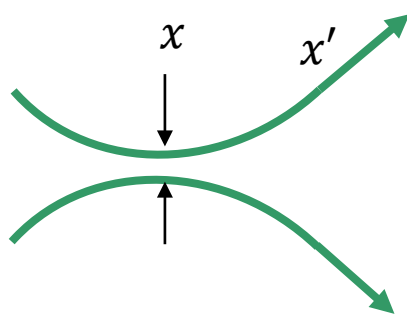
O3.4 Construction of a beam transport system for monochromatic low divergence 600 MeV positrons.

*T3.2 (Uni-Mainz, UNIFE, INFN) Design a setup for direct production of high-energy positrons with bremsstrahlung using the electron beam. Beam transport design for a low divergence positron beam from a conversion target. Radiation shielding simulations. **Experimental validation of the simulations.** Geant4 simulations for a position sensitive particle detector for the identification of positrons. Construction and test of such a detector at MAMI. Development of a low background detector for radiation measurements in the MeV region.*

Pair production with the MAMI beam in combination with a monochromator



High quality Positron beam @ MAMI



vertical

$$\begin{aligned} \text{MAMI: } \varepsilon_x &= x \cdot x' \\ &= 1 \text{ mm} \cdot \mu\text{rad} \\ &= 10 \mu\text{m} \cdot 0.1 \text{ mrad} \end{aligned}$$

Emittance

$$\varepsilon_x = x \cdot x' = \frac{F}{\pi} = \text{const}$$

Thin target for Positron production

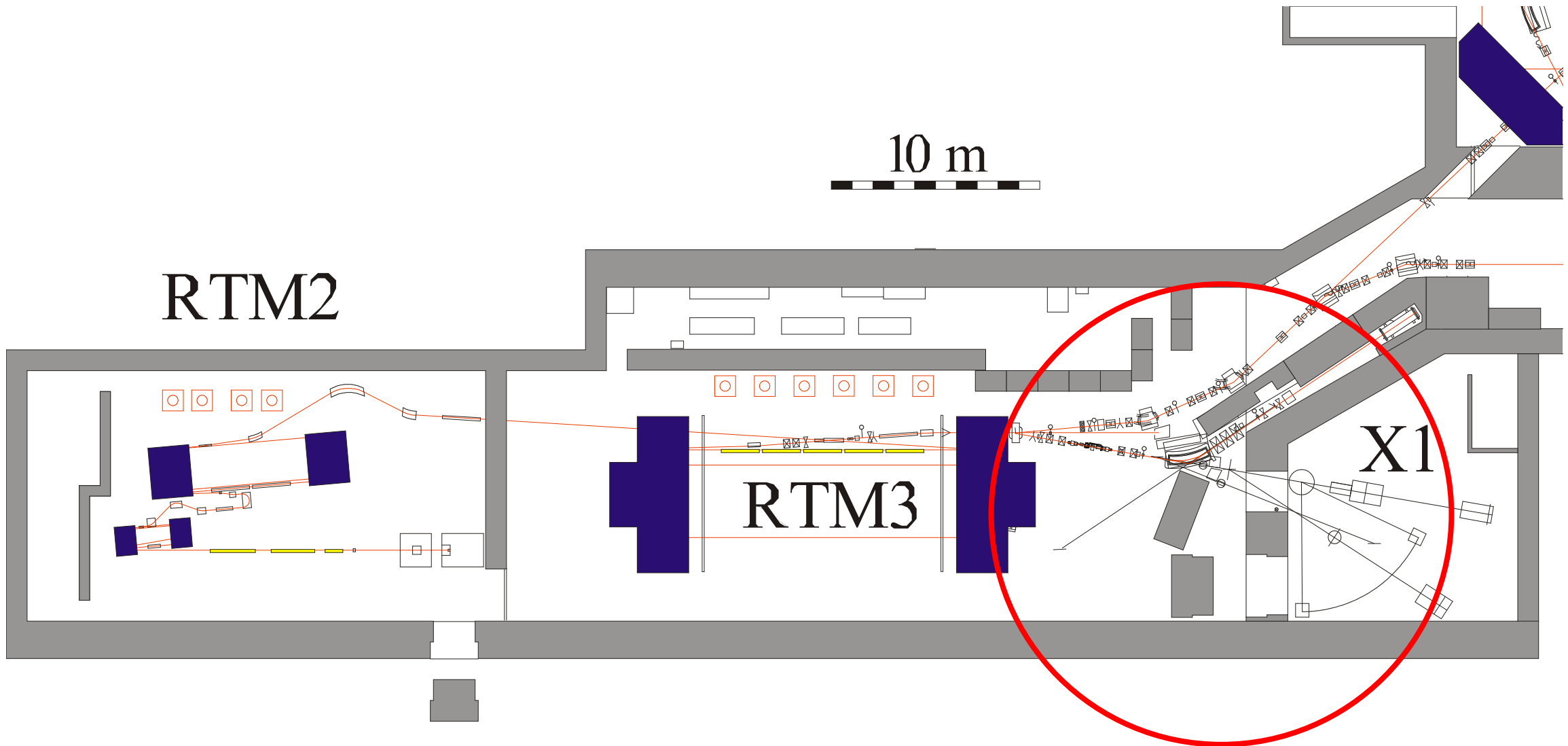
$10 \mu\text{m } W \rightarrow \text{Scattering } \sigma_s = 0.94 \text{ mrad}$

$$\sigma_p \cong \frac{1}{\gamma} = 1 \text{ mrad @500MeV}$$

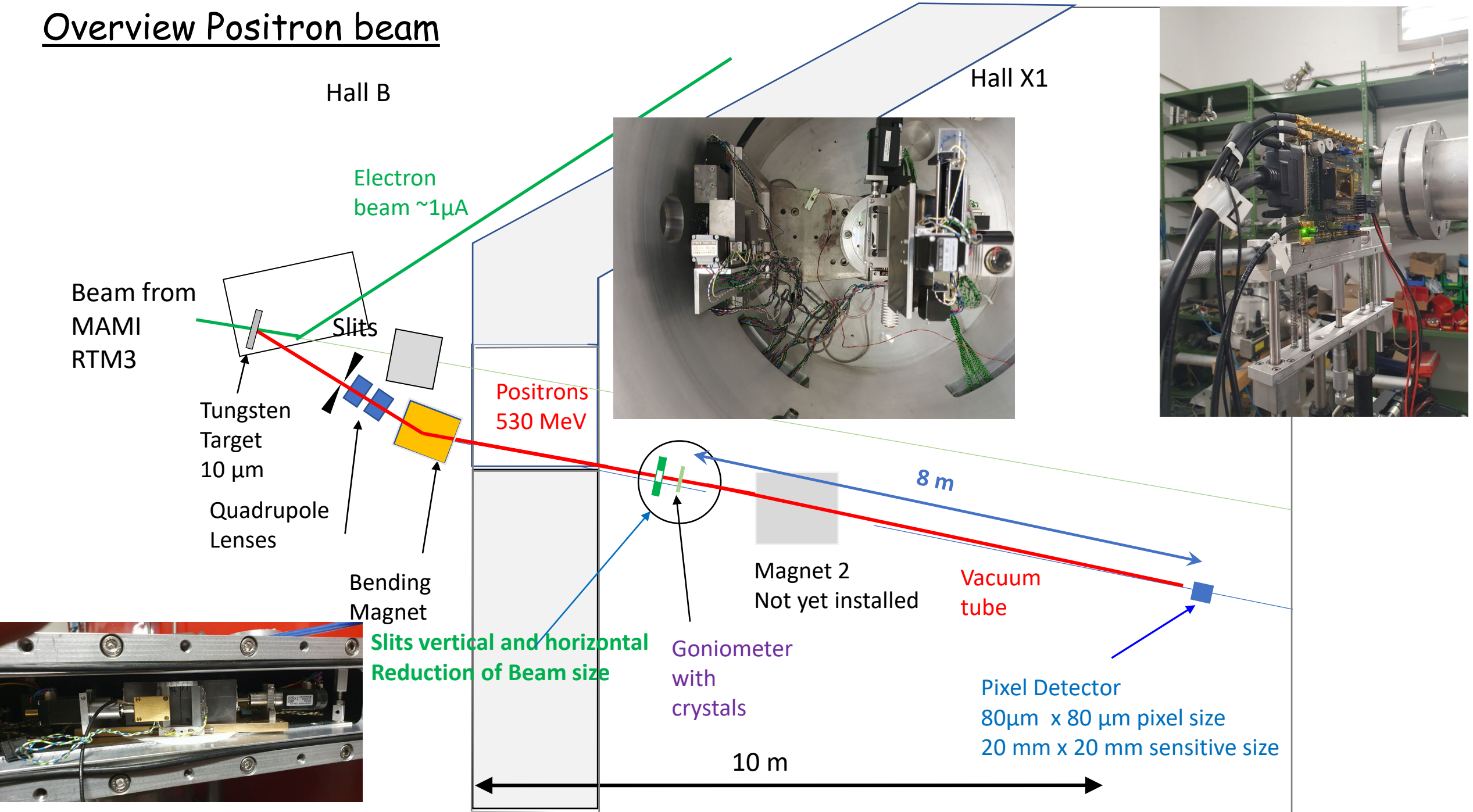
Emittance of Positrons:

$$\begin{aligned} \varepsilon_{e^+} &= 10 \mu\text{m} \cdot 1.4 \text{ mrad} \\ &= 1 \text{ mm} \cdot 0.014 \text{ mrad} \end{aligned}$$

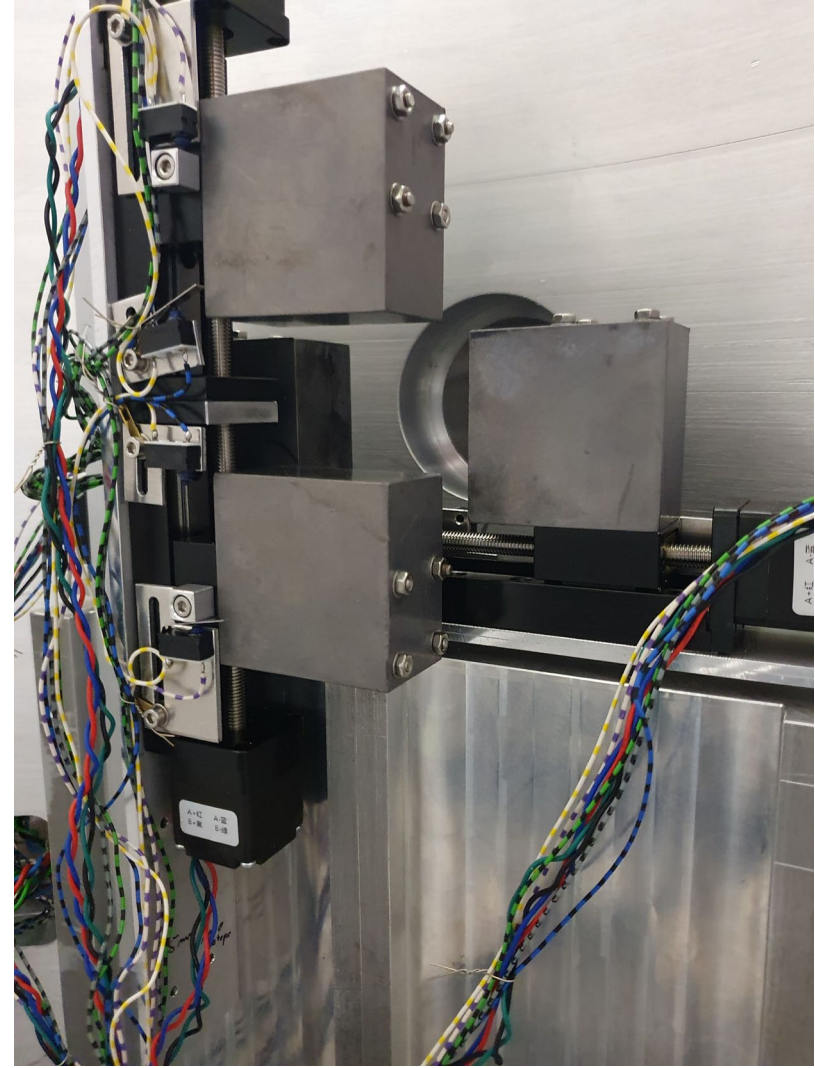
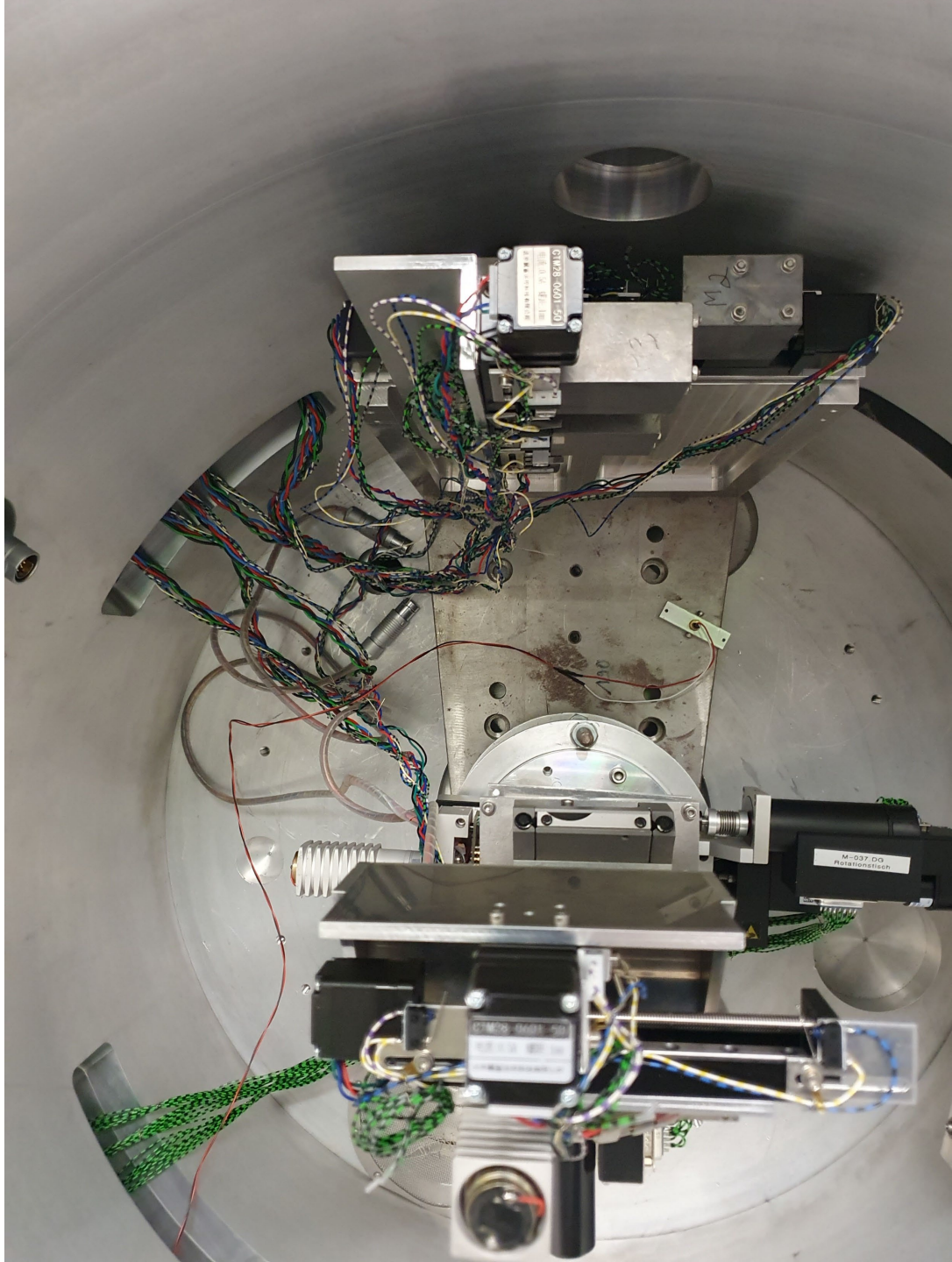
Production of high-energy positrons



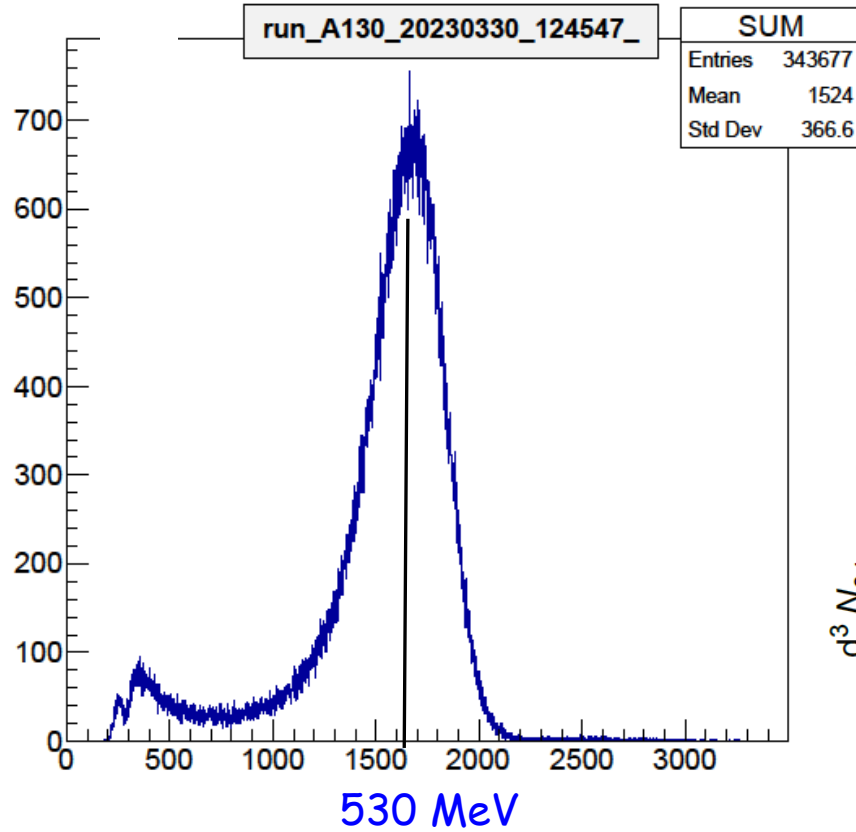
Overview Positron beam



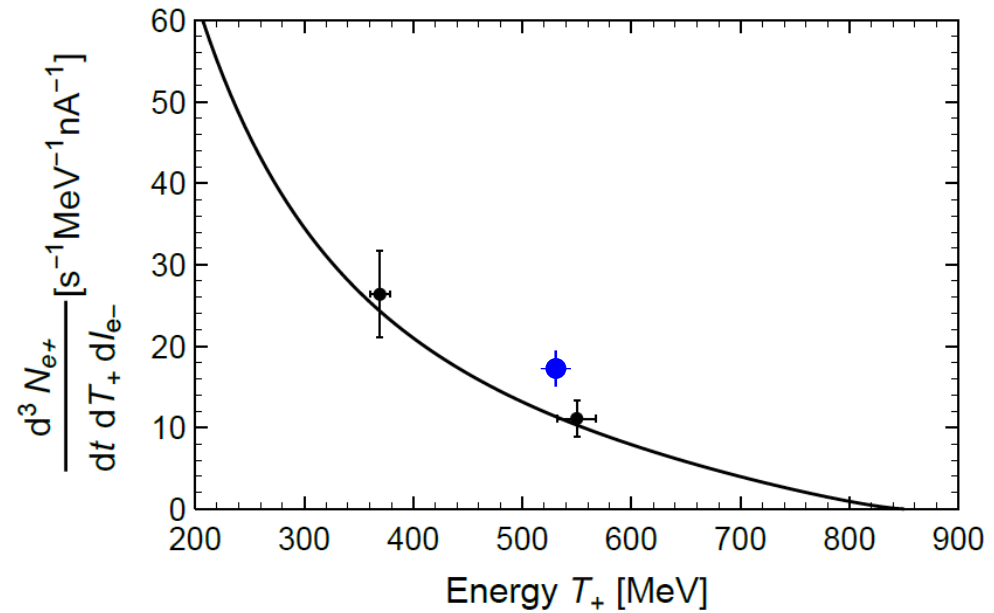




Production Rate



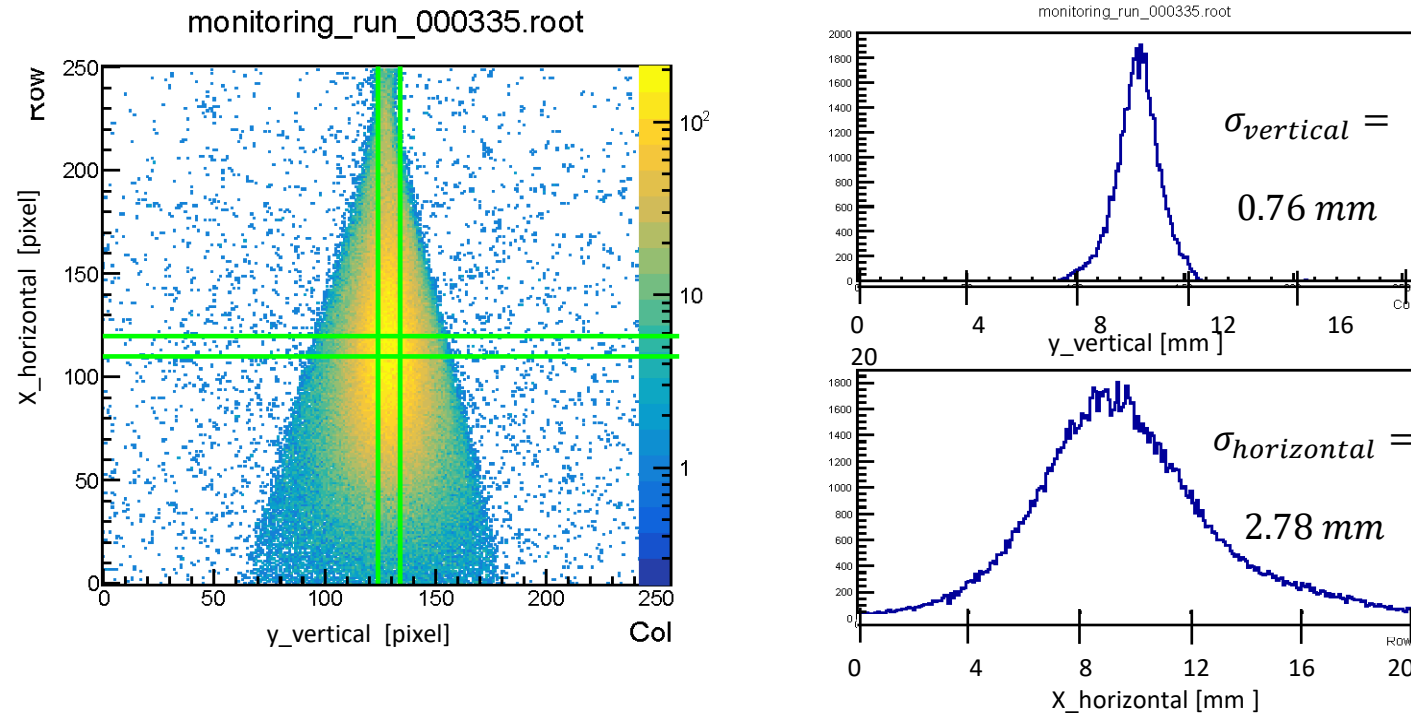
10 μm W Target
Slit width 3mm
 ~ 4.5 MeV



$$17.3 \frac{1}{\text{s} \cdot \text{nA} \cdot \text{MeV}}$$

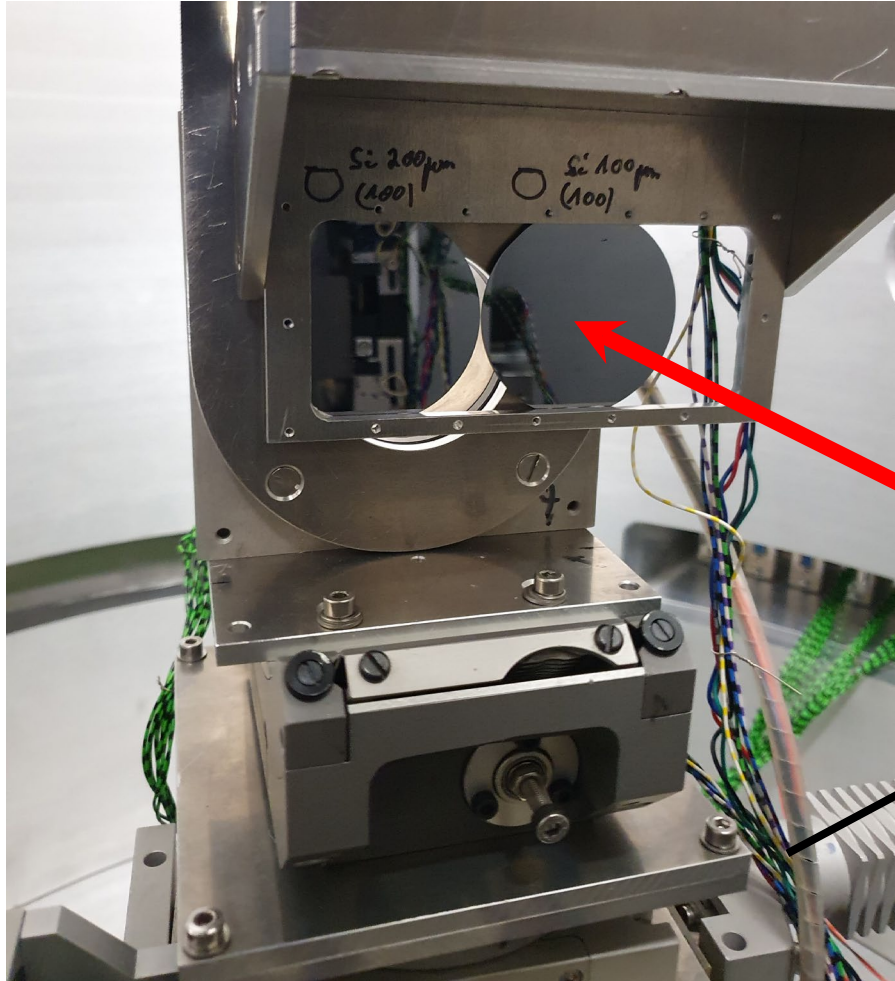
Max. e-current (without shielding) $\sim 1 \mu\text{A}$ \rightarrow
Max. positron rate **20 kHz**

Measurement of the beam size of the focused positron beam with the pixel detector



distance of 1.04 m from the centre of the crystal chamber

Channeling of Positrons in Si crystals

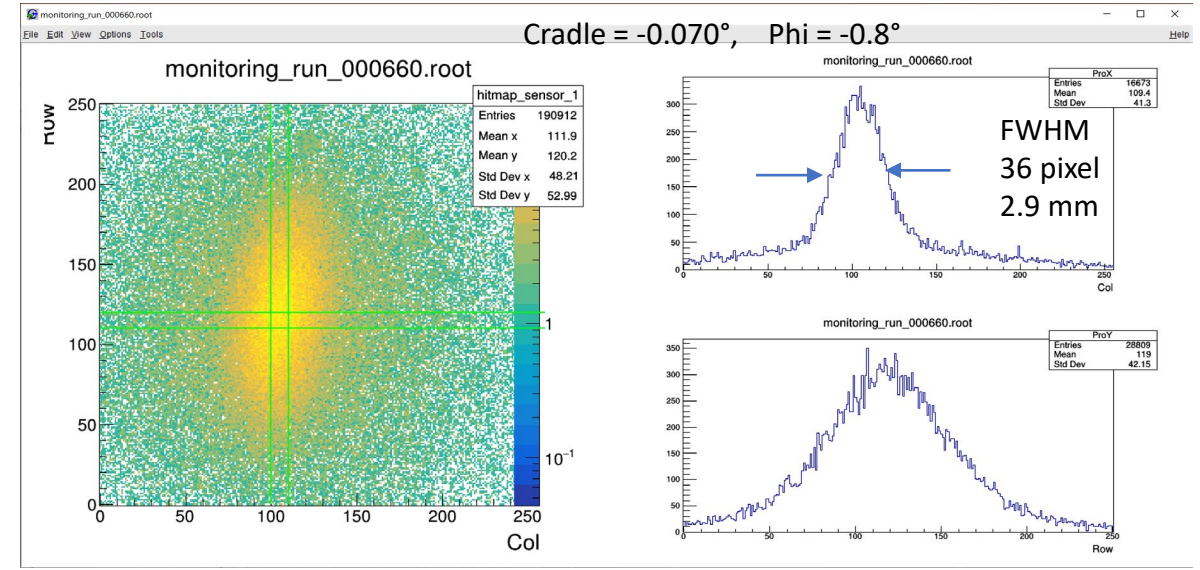
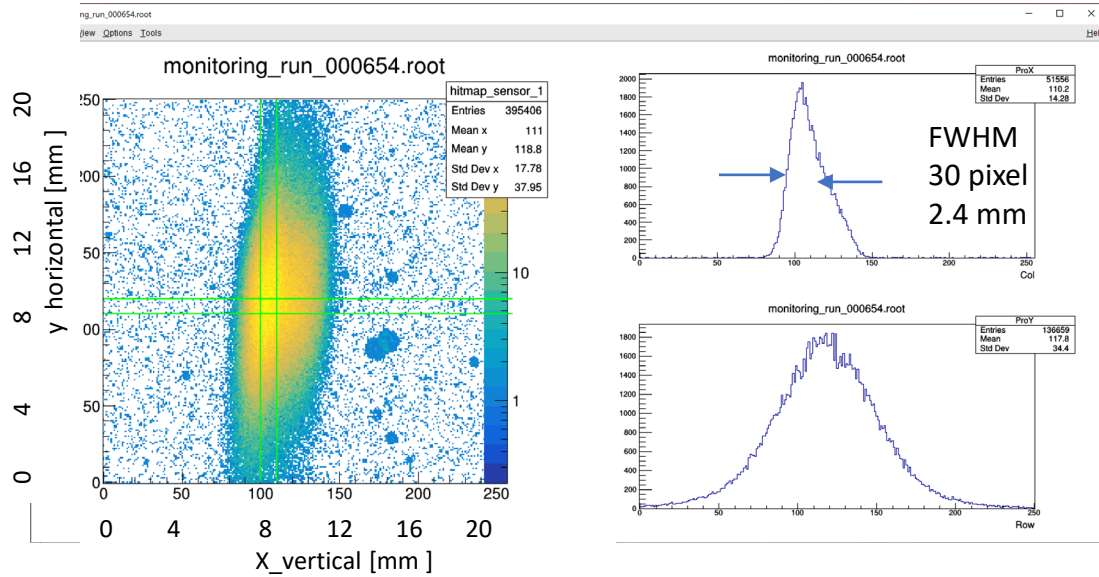


Detection of Positrons with pixel detector

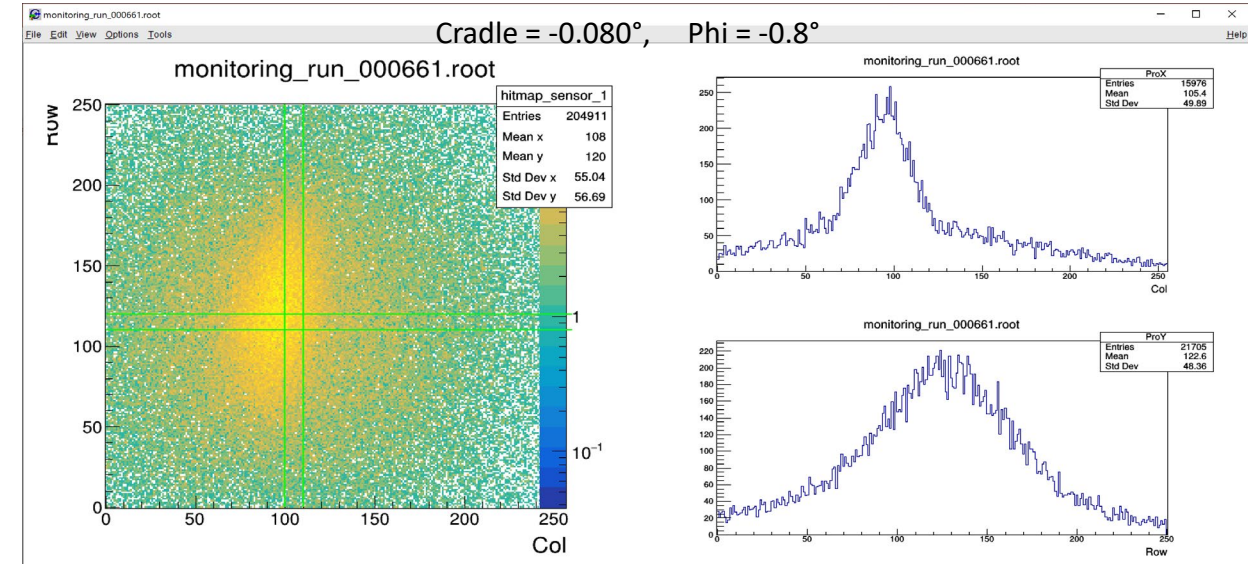
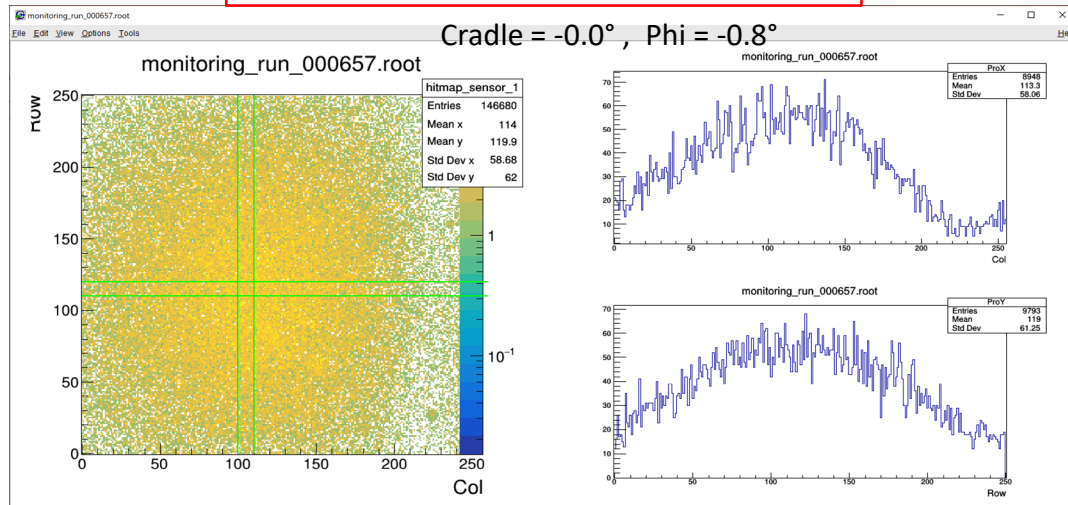
Without crystal

200 μm (100) Si crystal

With oriented crystal



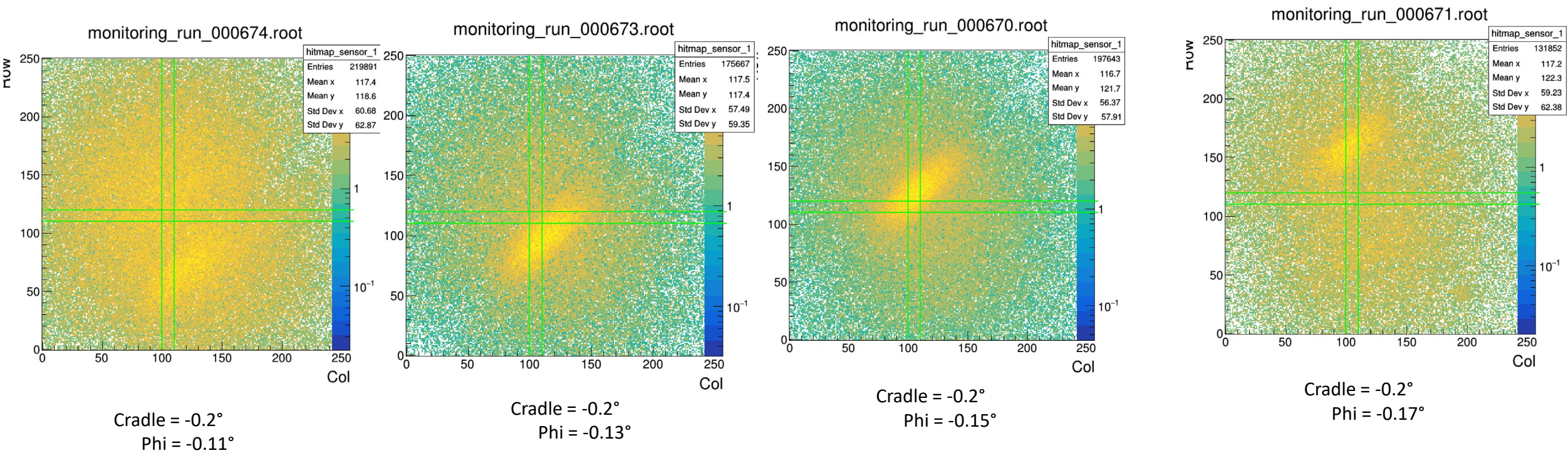
Random orientation of crystal



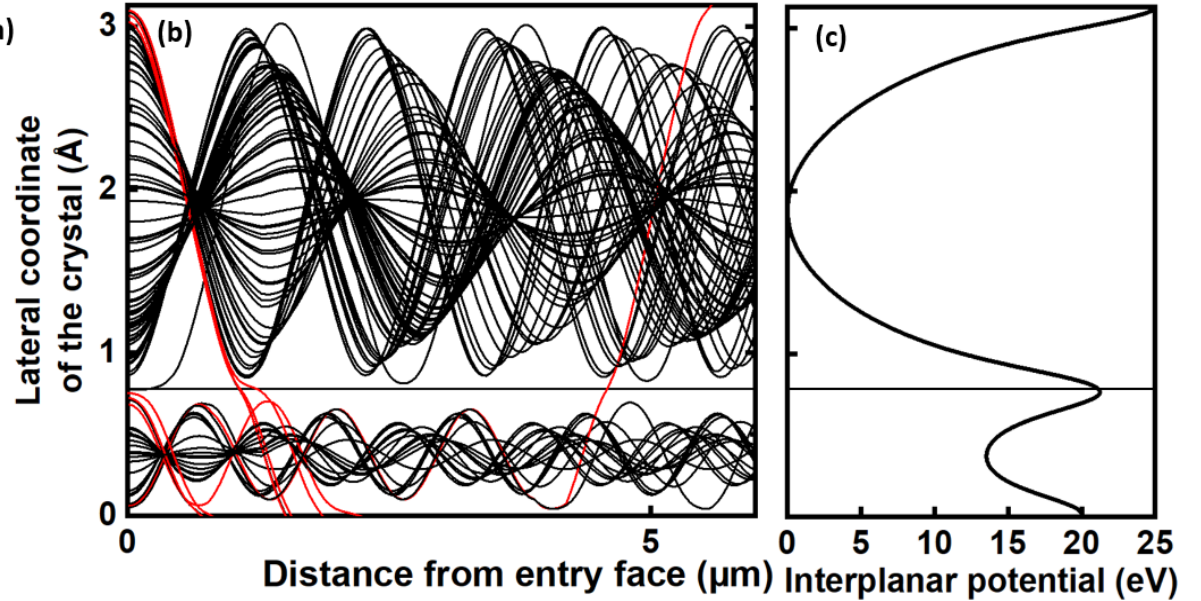
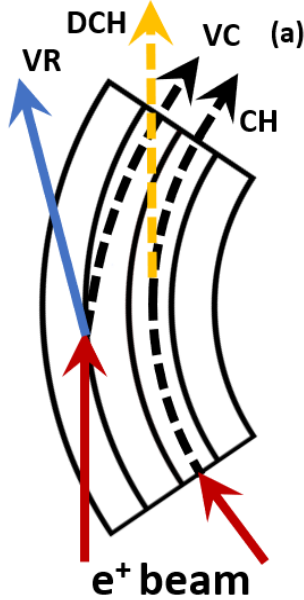
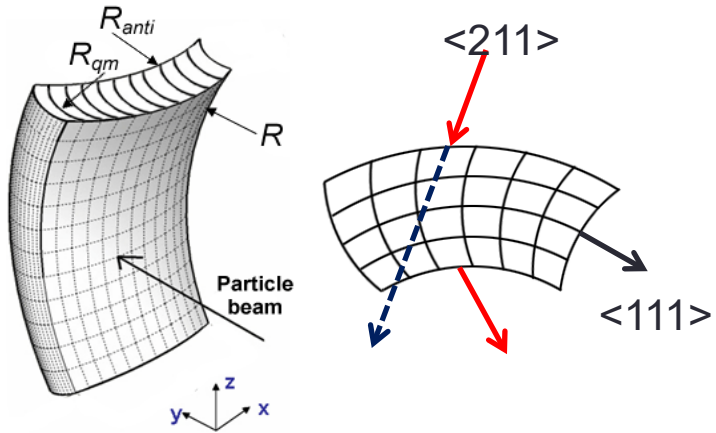
200 μm (100) Si crystal

110 Plane

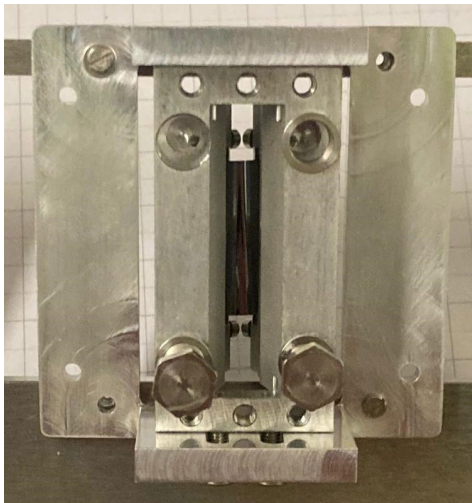
Rotation around vertical axis



Mechanically bent Si crystal test with 530 MeV positrons



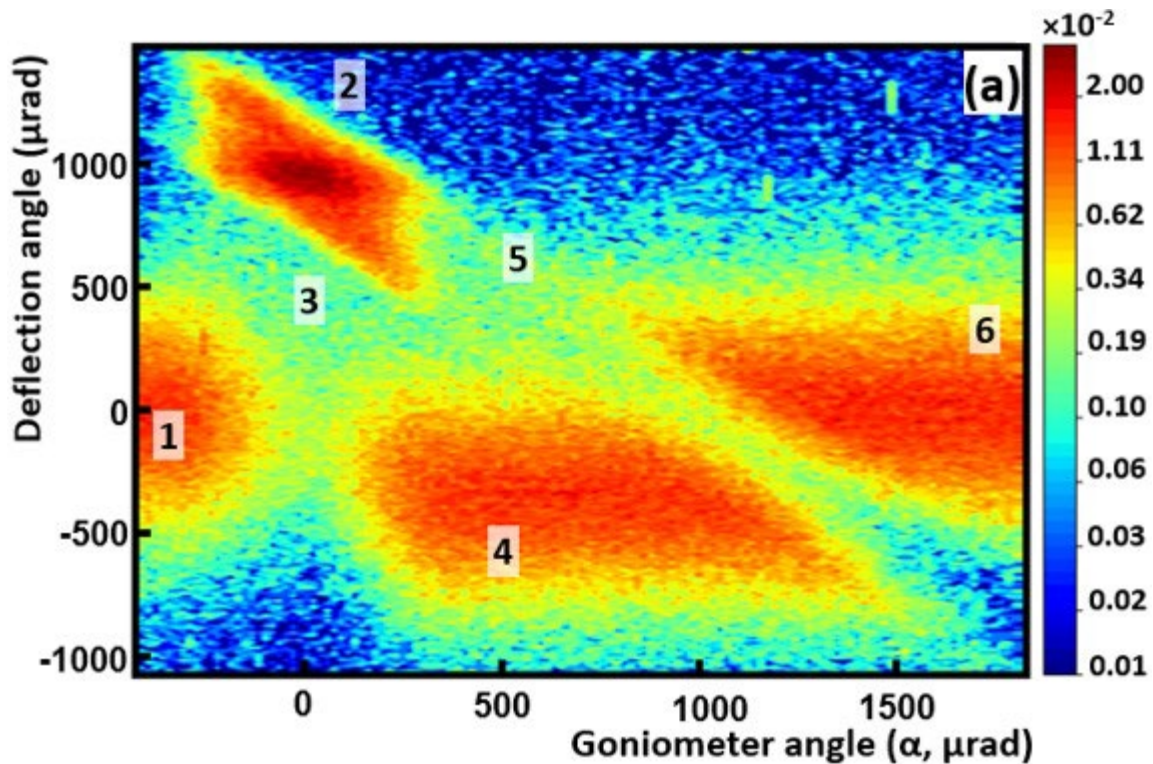
Guidi, V., et al., 2009. *Journal of Physics D Applied Physics* 42(18).
 Germogli, G., *NIM B*, 2015. 355: p. 81-85



Crystal label: **BC-Si-QMO***
 Thickness along the beam: $29.9 \pm 0.1 \mu\text{m}$ Bent planes, exploiting quasimosaic effect (111)
 Bending angle: $970 \pm 10 \mu\text{rad}$

**Crystal available from a previous project @*

Experimental results on beam steering of 530 MeV positrons



**TECHNO-CLS MILESTONE:
First high-efficient deflection of
sub-GeV positron worldwide !!!**

Fallout in :

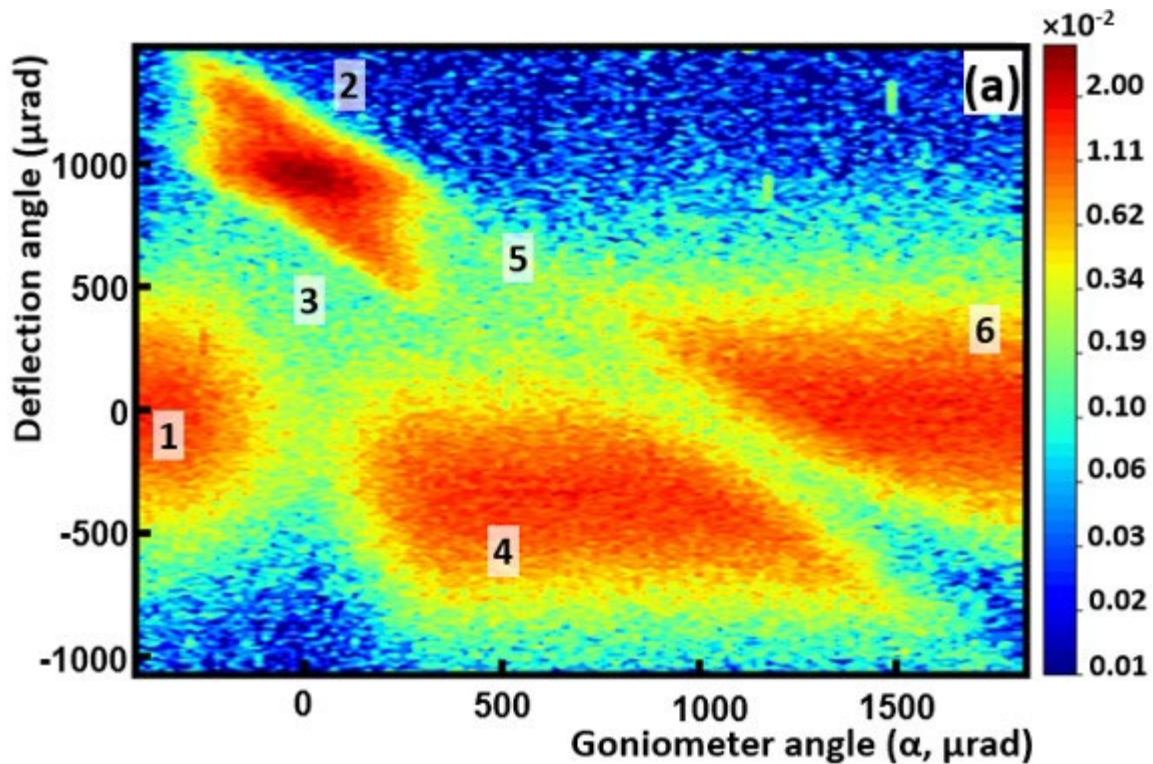
- Crystal-Light-Source
- Channeling based technologies
- Accelerator technologies: for beam steering, extraction, focusing..

Mazzolari, A., Backe, H., Bandiera, L., et al., (2024)
arXiv:2404.08459

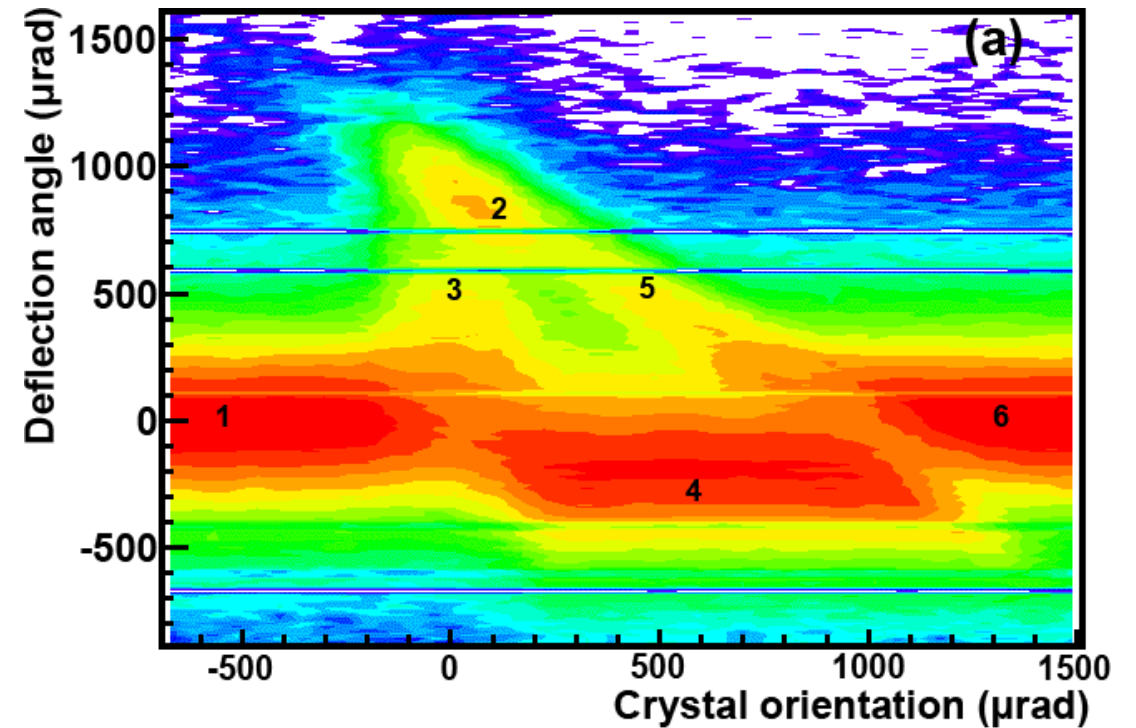
Open access paper on arXiv
Submitted to Phys. Rev. Lett.

530 MeV positrons* vs 855 MeV electrons**

Angular scan for deflected beam distribution: (1) and (6) nonchanneling regime; (2) channeling; (3) dechanneling; (4) volume reflection; and (5) volume capture.



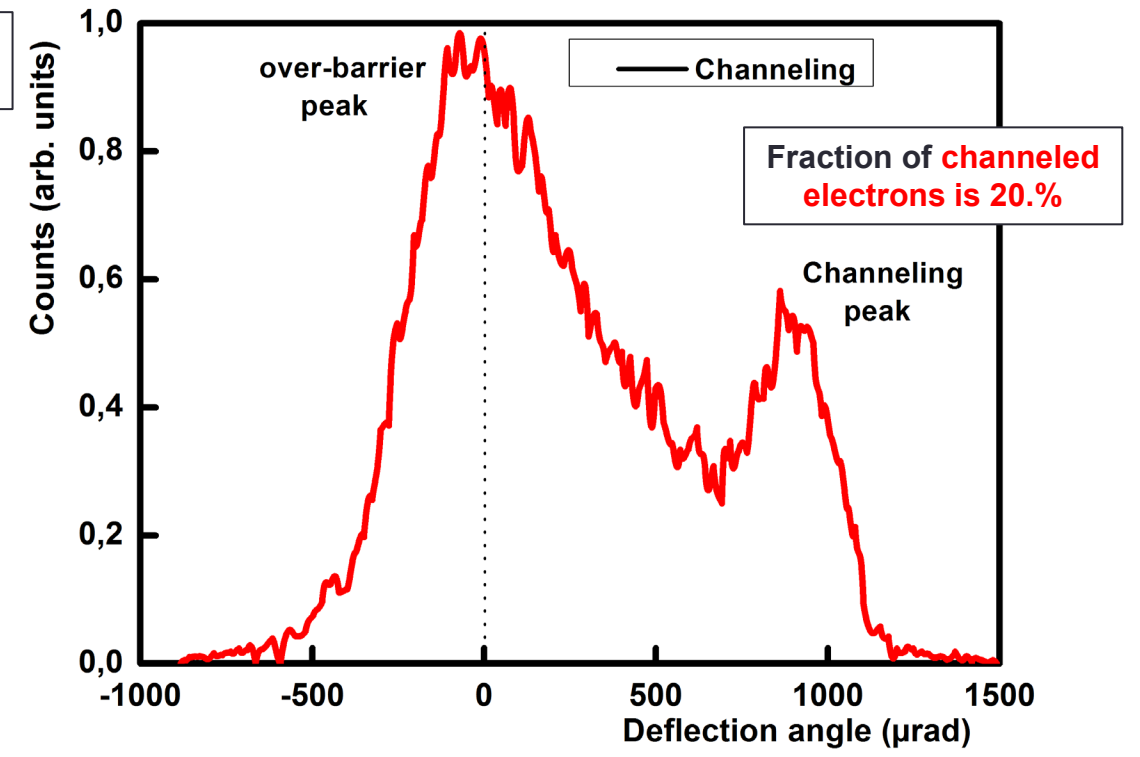
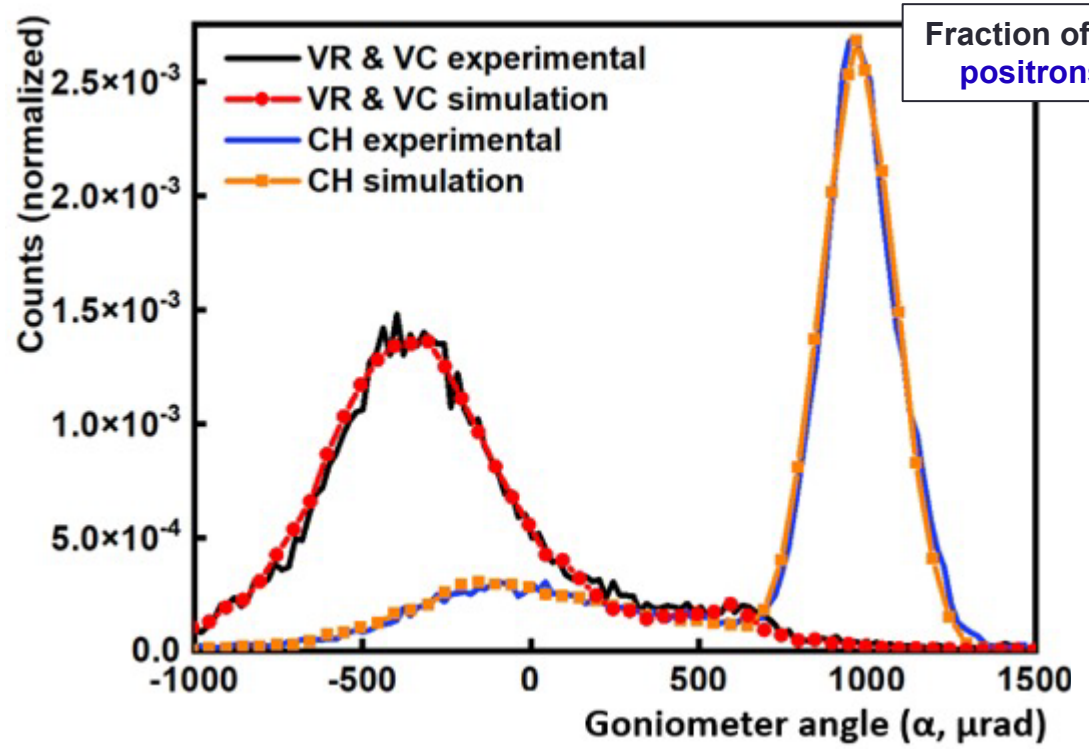
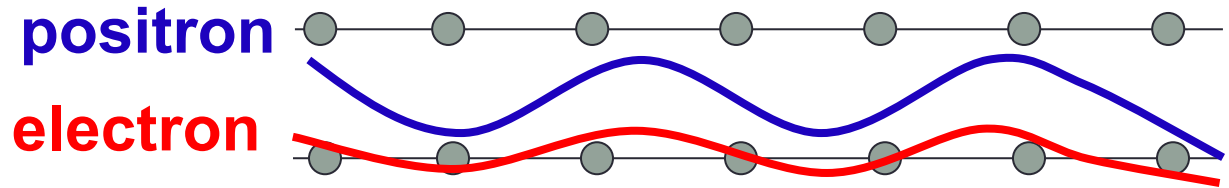
*Mazzolari, A., Backe, H., Bandiera, L., et al., (2024)
 arXiv:2404.08459



**Mazzolari A., Bagli E., Bandiera L., et al.,
 Phys. Rev. Lett. 112 (2014) 135503

Channeling efficiency e^+ vs e^-

Advantage of positrons for CLS \rightarrow higher channeling efficiency!



*Mazzolari, A., Backe, H., Bandiera, L., et al., (2024)
arXiv:2404.08459

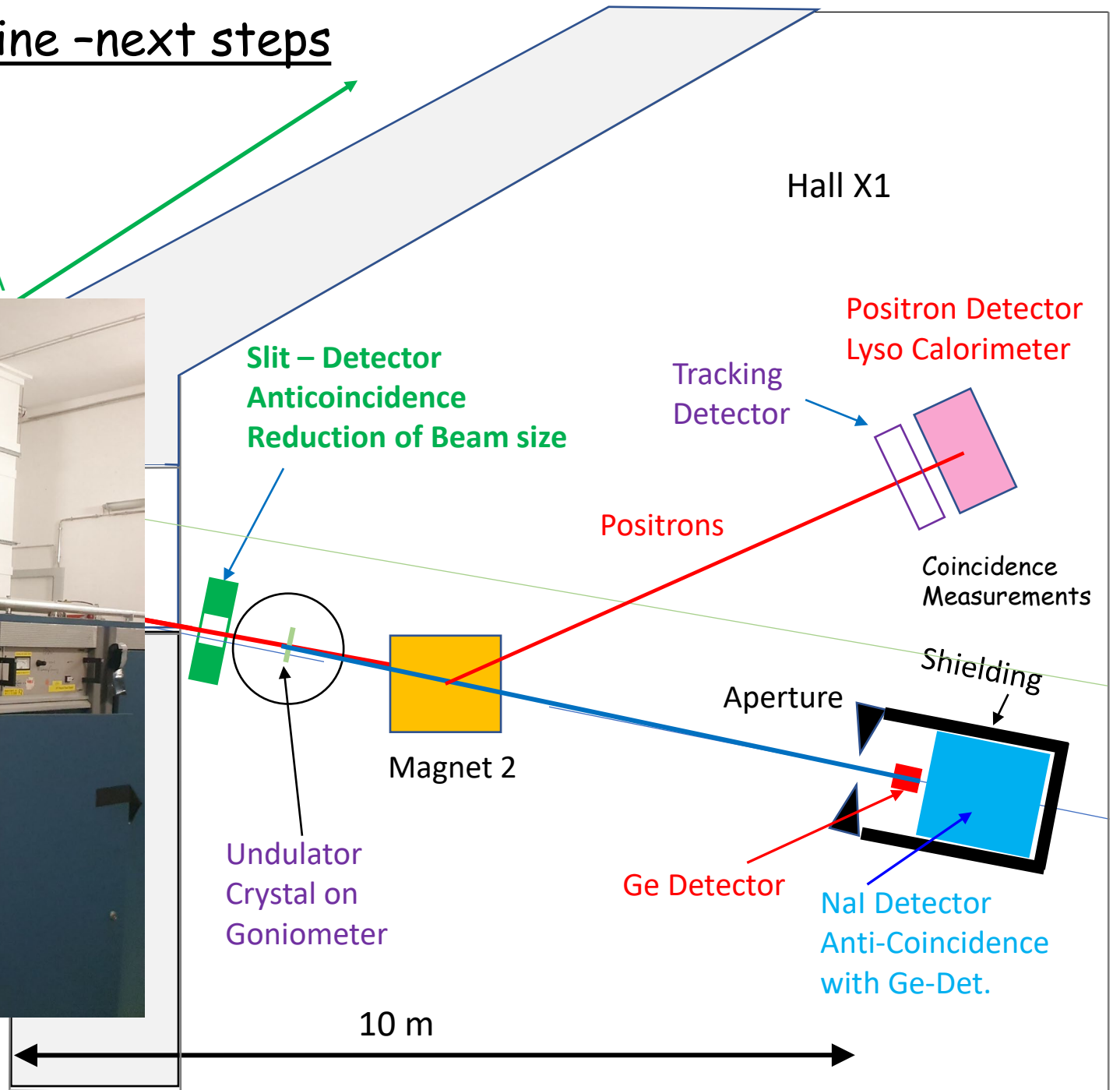
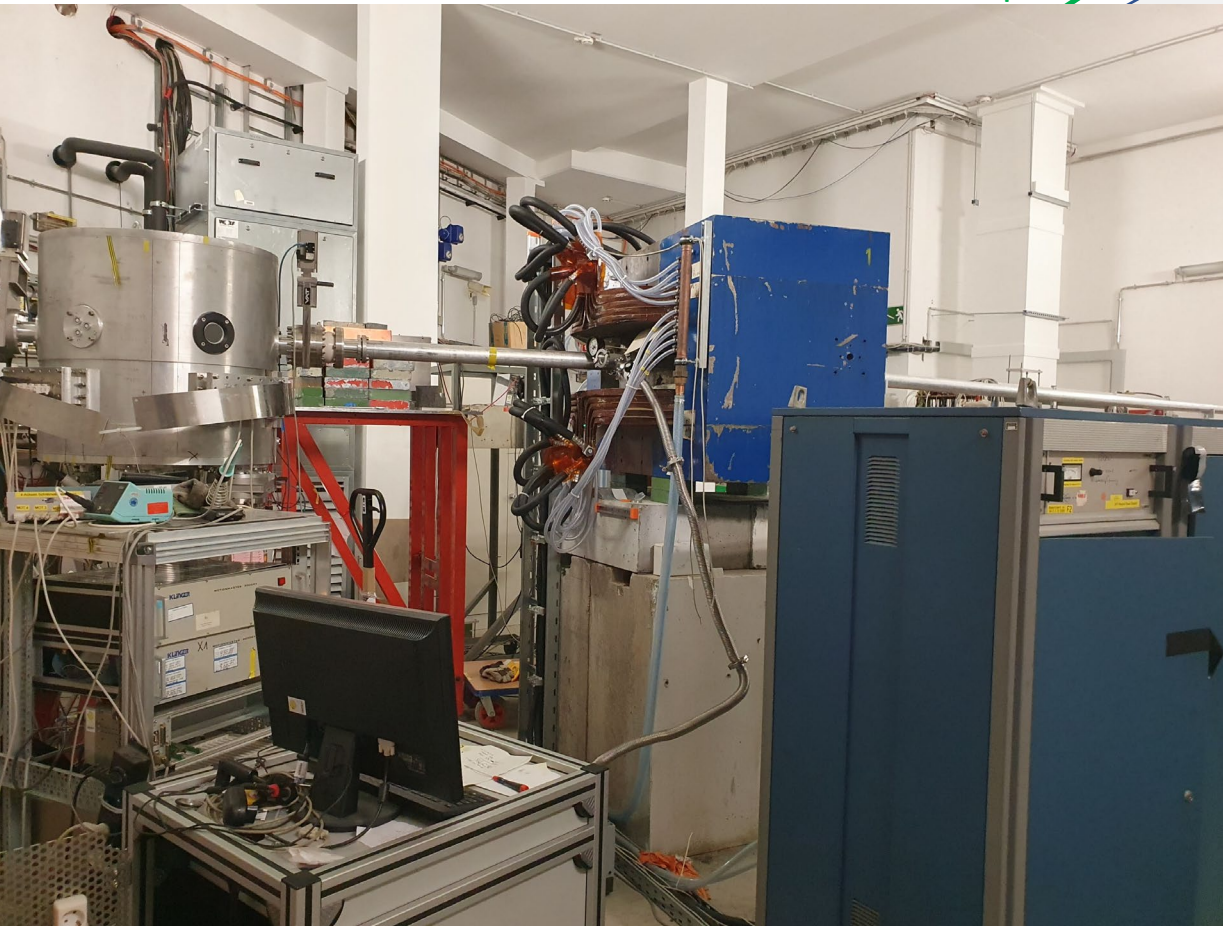
**Mazzolari A., Bagli E., Bandiera L., et al.,
Phys. Rev. Lett. 112 (2014) 135503

Overview Positron beam line -next steps

Hall B

Hall X1

Electron beam $\sim 1\mu\text{A}$



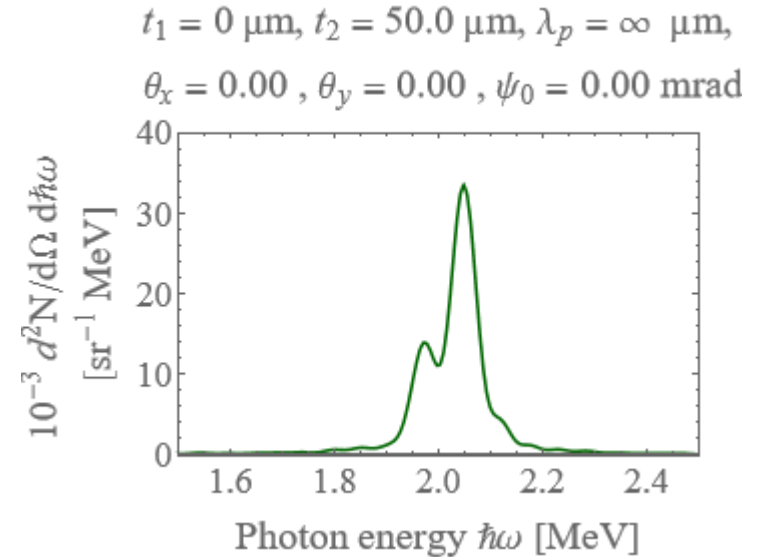
Future experiments with the Positron beam line

- Deflection of positrons ($\sqrt{}$)
- Channeling radiation with positrons / Tagging of channeling radiation
- Characterization of CLS Prototypes
- Dechanneling length measurements
- Undulator radiation with periodically bent crystals

Count rate estimation for channeling radiation

Calculation H. Backe et al., arXiv:2404.15376

- Positron rate: $\sim 2 \cdot 10^4$ Positrons/s
- Reduction of beam spot size 2mm
→ 5000 Positrons/s
- Solid angle $3 \cdot 10^{-7}$ sr
(d=4mm, Distance 6m)
- Integral Channeling photons $\sim 3000/ (e^+ \text{ sr})$



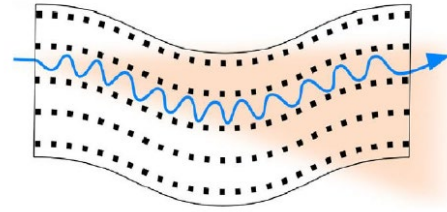
Total Count Rate = Photons/ $(e^+ \text{ sr})$ · Solid angle · Positrons/s

$$= 3000/ (e^+ \text{ sr}) \cdot 3 \cdot 10^{-7} \text{ sr} \cdot 5000 e^+ /s$$

$\sim 5/s$

Thanks for your attention

TECHNO-CLS



Horizon Europe EIC-Pathfinder Project
TECHNO-CLS: "Emerging technologies for
crystal-based gamma-ray light sources"



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